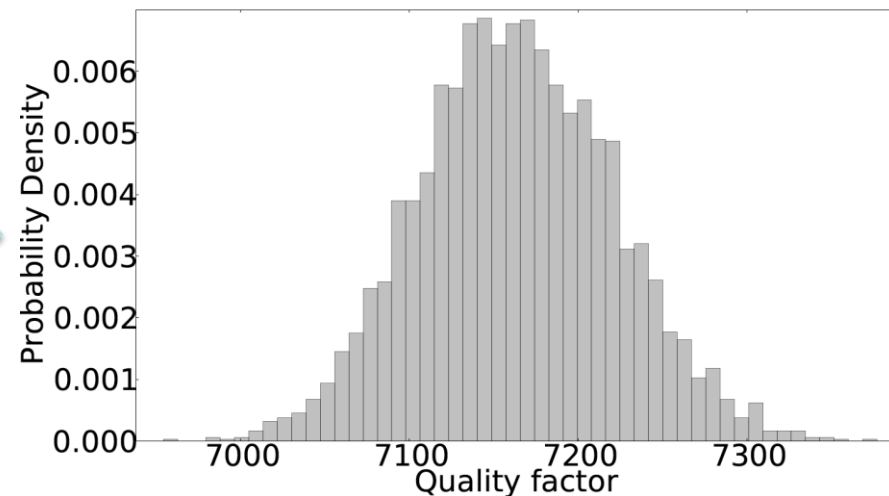
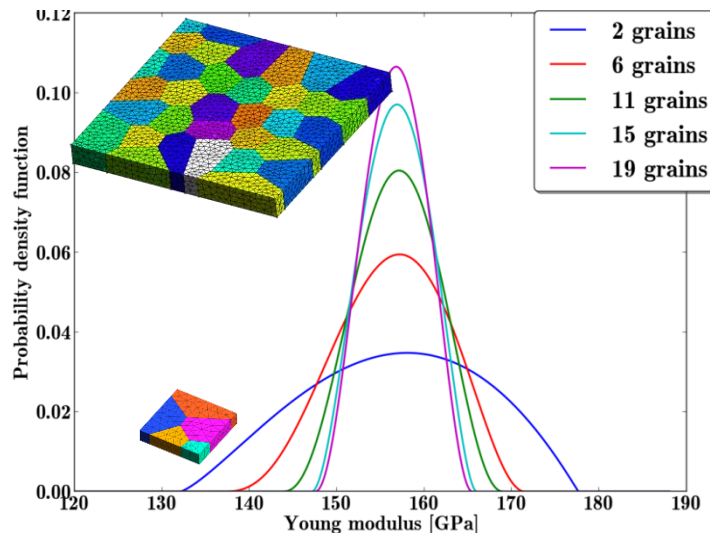


## A stochastic 3-scale method for polycrystalline materials

*Wu Ling, Lucas Vincent, Golinval Jean-Claude,  
Paquay Stéphane, Noels Ludovic*



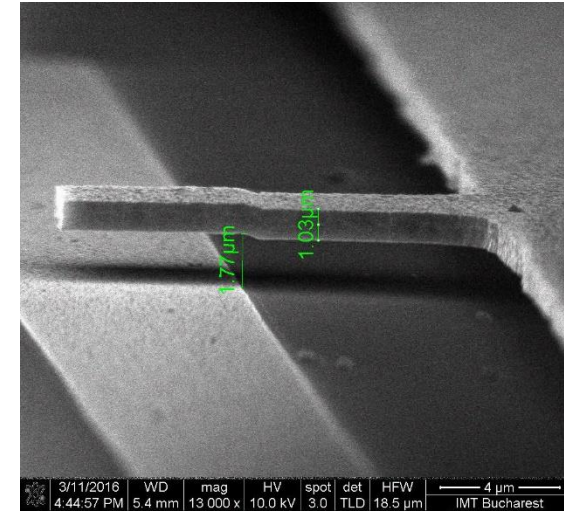
3SMVIB: The research has been funded by the Walloon Region under the agreement no 1117477 (CT-INT 2011-11-14) in the context of the ERA-NET MNT framework. Experimental measurements provided by IMT Bucharest (Voicu Rodica, Baracu Angela, Muller Raluca)

# The problem

- MEMS structures

- Are not several orders larger than their micro-structure size
- Parameters-dependent manufacturing process
  - Low Pressure Chemical Vapor Deposition (LPCVD)
  - Properties depend on the temperature, time process, and flow gas conditions
- Scatter in the structural properties
  - Due to the fabrication process (photolithography, etching ...)
  - Due to uncertainties of the material
  - ...

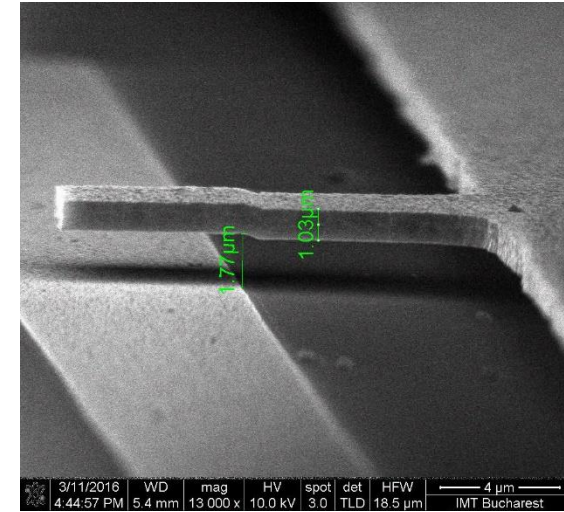
➔ The objective of this work is to estimate this scatter



# The problem

- MEMS structures

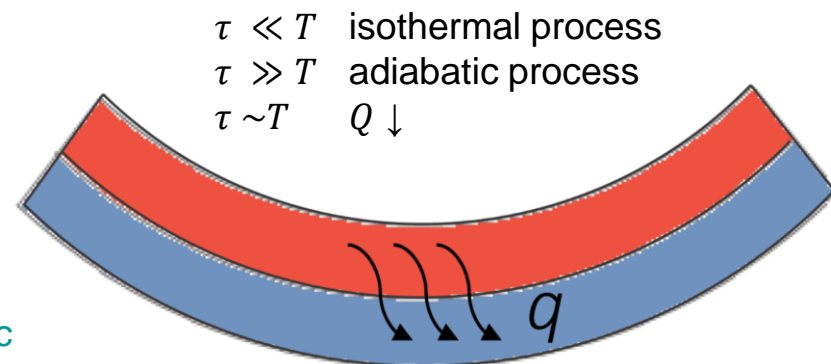
- Are not several orders larger than their micro-structure size
- Parameters-dependent manufacturing process
  - Low Pressure Chemical Vapor Deposition (LPCVD)
  - Properties depend on the temperature, time process, and flow gas conditions
- Scatter in the structural properties
  - Due to the fabrication process (photolithography, etching ...)
  - Due to uncertainties of the material
  - ...



→ The objective of this work is to estimate this scatter

- Application example

- Poly-silicon resonators
- Quantities of interest
  - Eigen frequency
  - Quality factor due to thermoelastic damping  $Q \sim W/\Delta W$
  - Thermoelastic damping is a source of intrinsic material damping present in almost all materials

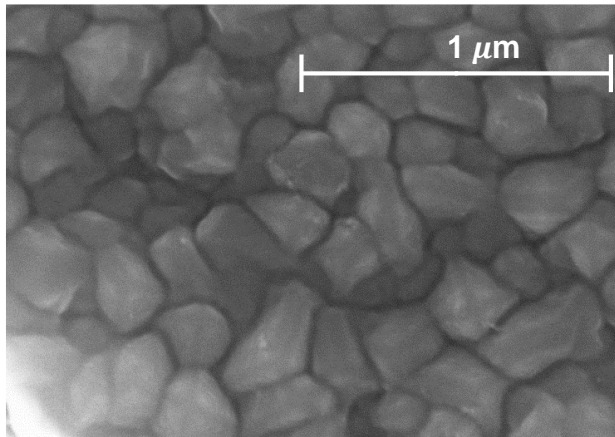


# The problem

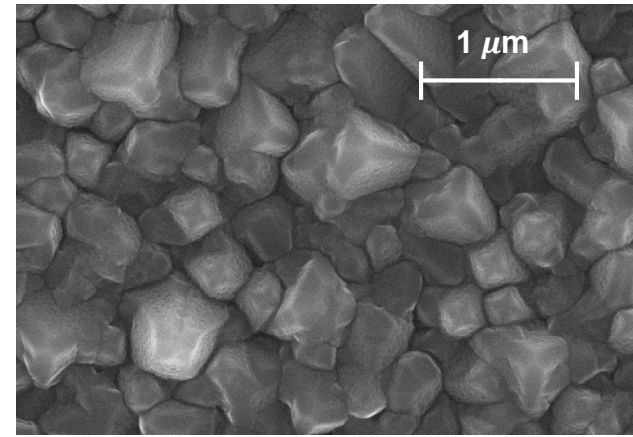
- Material structure: grain size distribution

## SEM Measurements (Scanning Electron Microscope)

- Grain size dependent on the LPCVD temperature process
- 2  $\mu\text{m}$ -thick poly-silicon films



Deposition temperature: 580 °C



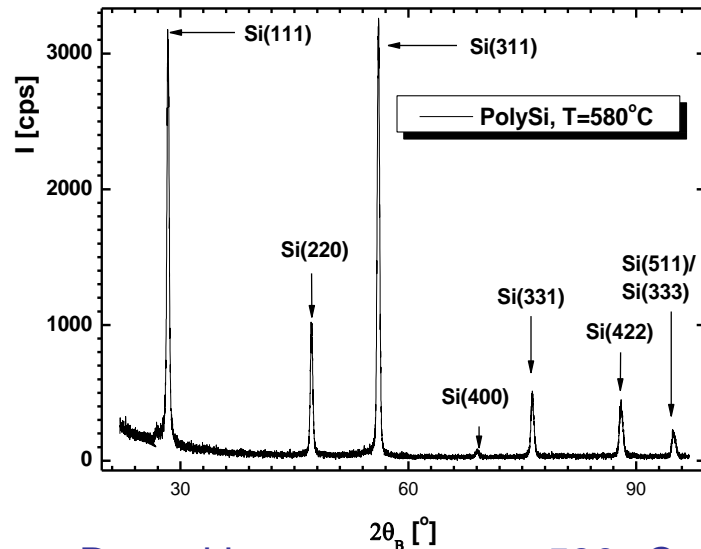
Deposition temperature: 650 °C

Deposition temperature [°C]	580	610	630	650
Average grain diameter [ $\mu\text{m}$ ]	0.21	0.45	0.72	0.83

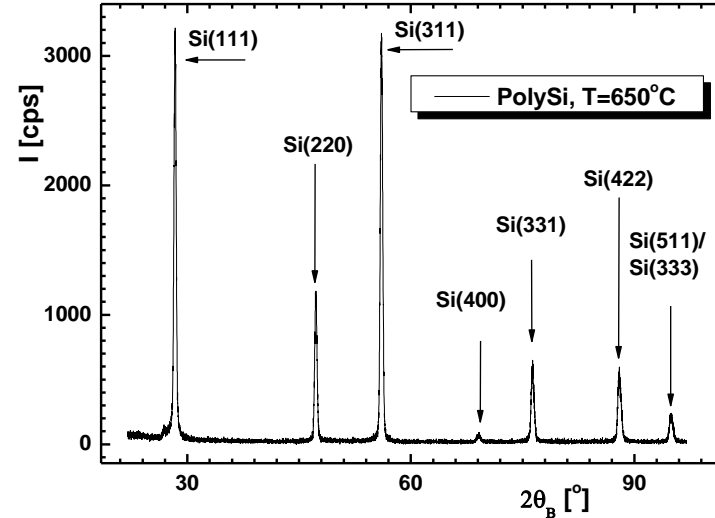
SEM images provided by IMT Bucharest, Rodica Voicu, Angela Baracu, Raluca Muller

# The problem

- Material structure: grain orientation distribution
  - Grain orientation by XRD (X-ray Diffraction) measurements on 2  $\mu\text{m}$ -thick poly-silicon films



Deposition temperature: 580 °C



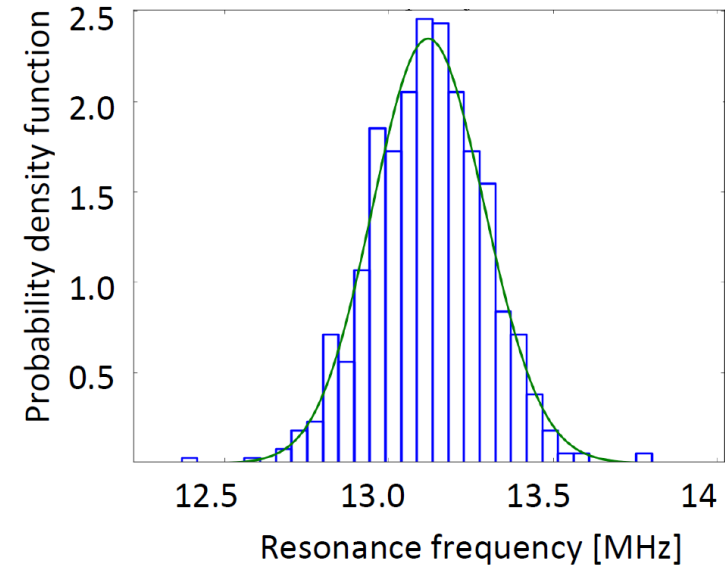
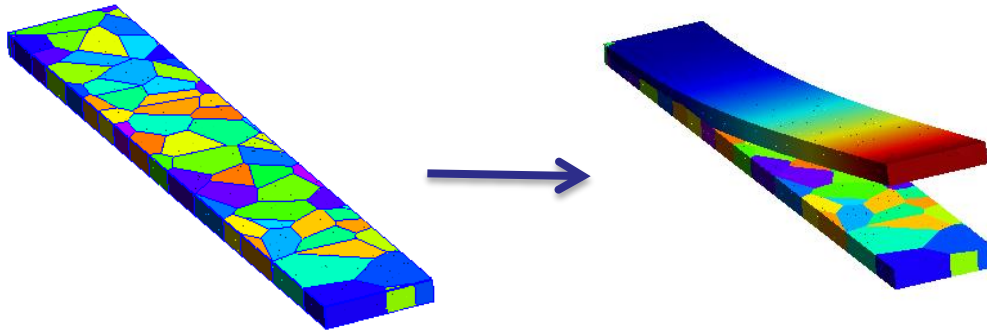
Deposition temperature: 630 °C

Deposition temperature [°C]	580	610	630	650
<111> [%]	12.57	19.96	12.88	11.72
<220> [%]	7.19	13.67	7.96	7.59
<311> [%]	42.83	28.83	39.08	38.47
<400> [%]	4.28	5.54	3.13	3.93
<331> [%]	17.97	18.14	21.32	20.45
<422> [%]	15.15	13.86	15.63	17.84

XRD images provided by IMT Bucharest, Rodica Voicu, Angela Baracu, Raluca Muller

# Monte-Carlo for a fully modelled beam

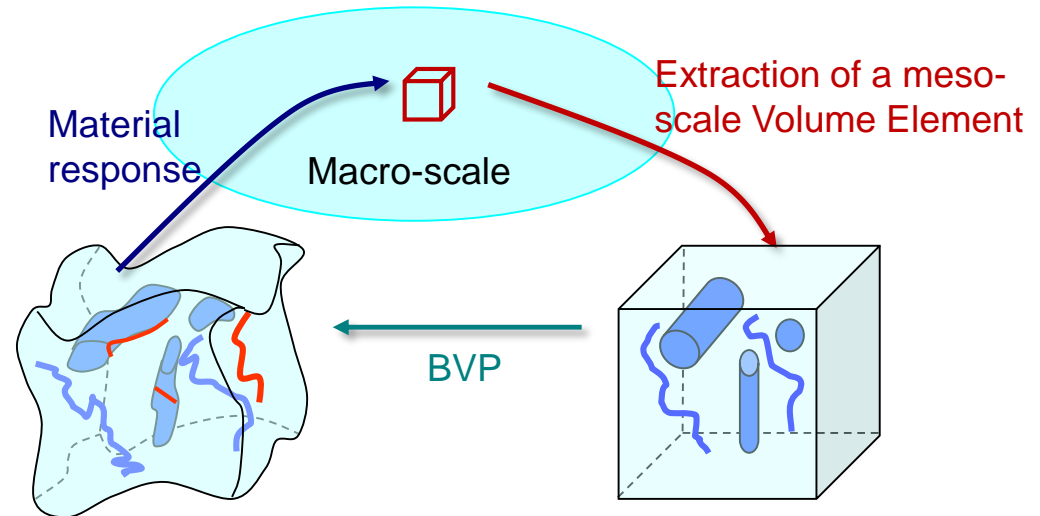
- The first mode frequency distribution can be obtained with
  - A 3D beam with each grain modelled
  - Grains distribution according to experimental measurements
  - Monte-Carlo simulations



- Considering each grain is expensive and time consuming
  - ↳ **Motivation for stochastic multi-scale methods**

- Multi-scale modelling

- 2 problems are solved concurrently
  - The macro-scale problem
  - The meso-scale problem (on a meso-scale Volume Element)



- Length-scales separation

$$L_{\text{macro}} \gg L_{\text{VE}} \gg L_{\text{micro}}$$

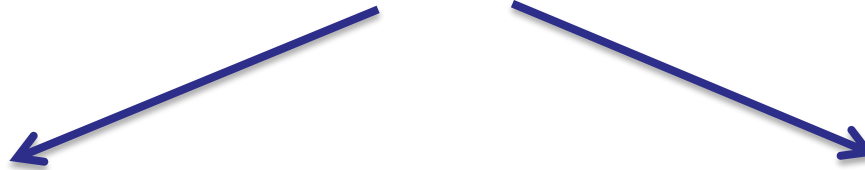
For accuracy: Size of the meso-scale volume element smaller than the characteristic length of the macro-scale loading

To be statistically representative: Size of the meso-scale volume element larger than the characteristic length of the micro-structure

# Motivations

- For structures not several orders larger than the micro-structure size

$$L_{\text{macro}} \gg L_{\text{VE}} \sim L_{\text{micro}}$$



For accuracy: Size of the meso-scale volume element smaller than the characteristic length of the macro-scale loading

Meso-scale volume element no longer statistically representative: Stochastic Volume Elements\*

- Possibility to propagate the uncertainties from the micro-scale to the macro-scale

\*M Ostoja-Starzewski, X Wang, 1999

P Trovalusci, M Ostoja-Starzewski, M L De Bellis, A Murralli, 2015

X. Yin, W. Chen, A. To, C. McVeigh, 2008

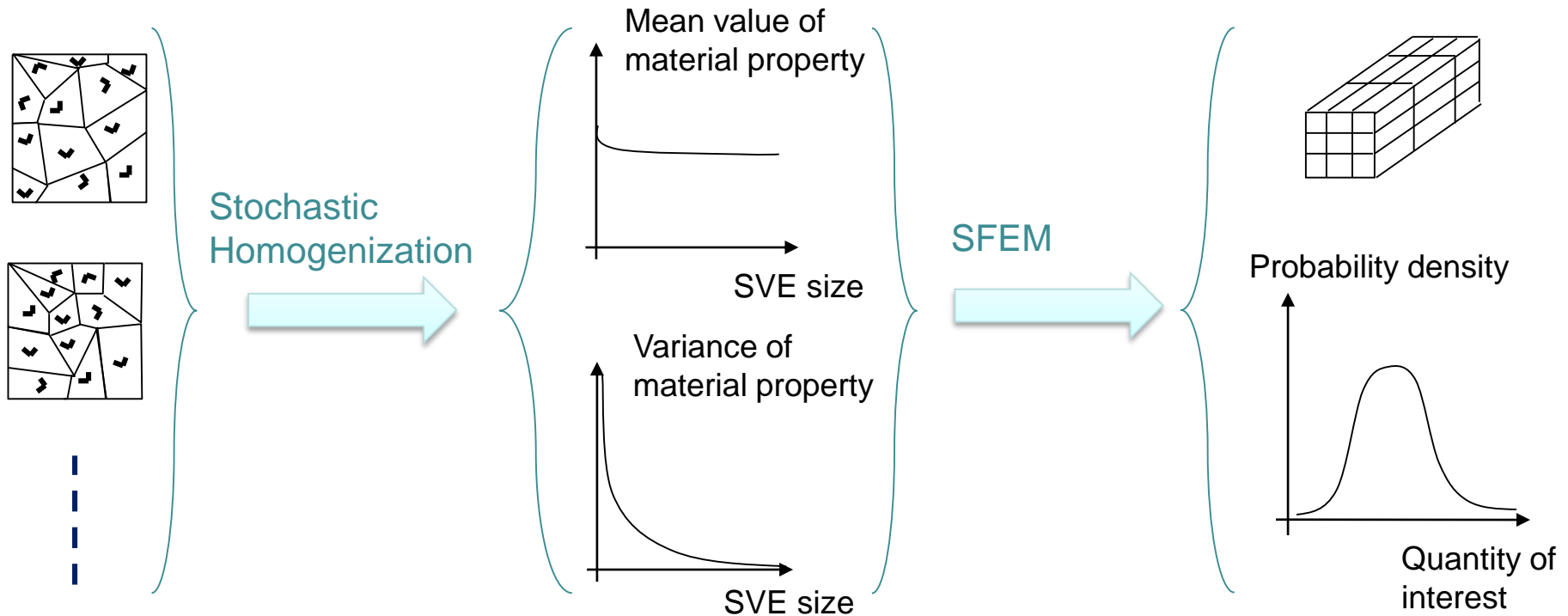
J. Guillemot, A. Noshadravan, C. Soize, R. Ghanem, 2011

....



# A 3-scale process

Grain-scale or micro-scale	Meso-scale	Macro-scale
<ul style="list-style-type: none"> <li>➤ Samples of the microstructure (volume elements) are generated</li> <li>➤ Each grain has a random orientation</li> </ul>	<ul style="list-style-type: none"> <li>➤ Intermediate scale</li> <li>➤ The distribution of the material property <math>\mathbb{P}(C)</math> is defined</li> </ul>	<ul style="list-style-type: none"> <li>➤ Uncertainty quantification of the macro-scale quantity</li> <li>➤ E.g. the first mode frequency <math>\mathbb{P}(f_1)</math> /Quality factor <math>\mathbb{P}(Q)</math></li> </ul>



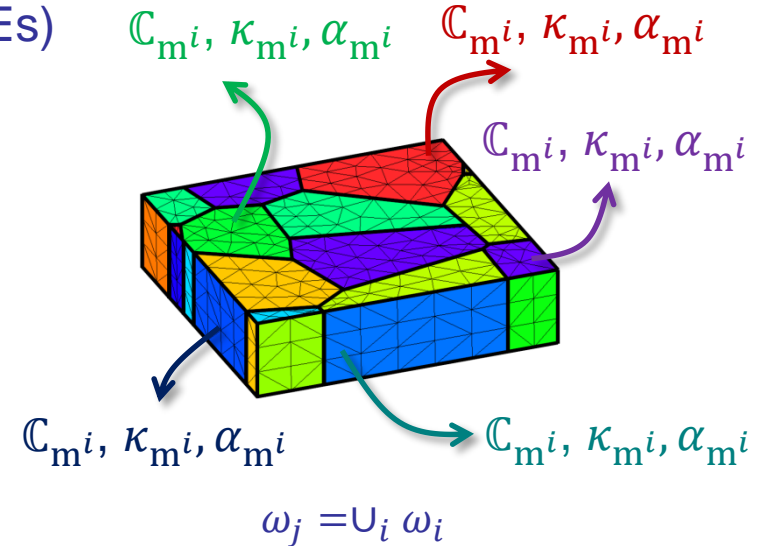
- From the micro-scale to the meso-scale
  - Thermo-mechanical homogenization
  - Definition of Stochastic Volume Elements (SVEs) & Stochastic homogenization
  - Need for a meso-scale random field
- The meso-scale random field
  - Definition of the thermo-mechanical meso-scale random field
  - Stochastic model of the random field: Spectral generator & non-Gaussian mapping
- From the meso-scale to the macro-scale
  - 3-Scale approach verification
  - Application to extract the quality factor
- Accounting for roughness effect
  - From the micro-scale to the meso-scale
  - The meso-scale random field
  - From the meso-scale to the macro-scale

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# From the micro-scale to the meso-scale

- Definition of Stochastic Volume Elements (SVEs)

- Poisson Voronoï tessellation realizations
  - SVE realization  $\omega_j$
- Each grain  $\omega_i$  is assigned material properties
  - Elasticity tensor  $\mathbb{C}_{m^i}$ ;
  - Heat conductivity tensor  $\kappa_{m^i}$ ;
  - Thermal expansion tensors  $\alpha_{m^i}$ .
  - Defined from silicon crystal properties
- Each set  $\mathbb{C}_{m^i}, \kappa_{m^i}, \alpha_{m^i}$  is assigned a random orientation
  - Following XRD distributions



- Stochastic homogenization

- Several SVE realizations
- For each SVE  $\omega_j = \cup_i \omega_i$

$$\mathbb{C}_{m^i}, \kappa_{m^i}, \alpha_{m^i} \quad \forall i$$



Computational  
homogenization

$$\mathbb{C}_{M^j}, \kappa_{M^j}, \alpha_{M^j}$$

Samples of the meso-  
scale homogenized  
elasticity tensors

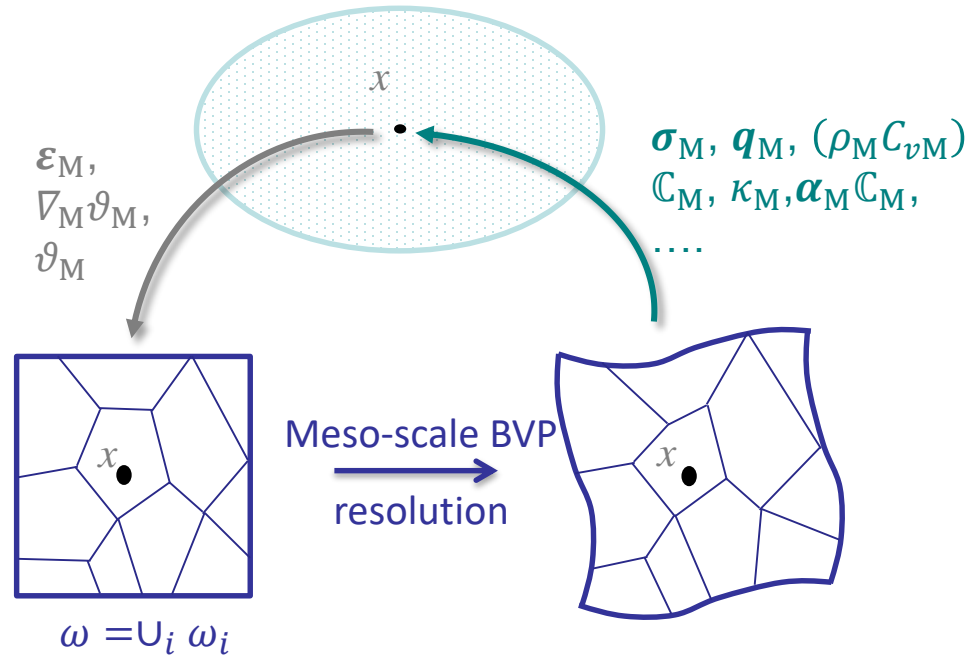
- Homogenized material tensors not unique as statistical representativeness is lost\*

\*C. Huet, 1990

- Thermo-mechanical homogenization

- Down-scaling

$$\left\{ \begin{array}{l} \varepsilon_M = \frac{1}{V(\omega)} \int_{\omega} \varepsilon_m d\omega \\ \nabla_M \vartheta_M = \frac{1}{V(\omega)} \int_{\omega} \nabla_m \vartheta_m d\omega \\ \vartheta_M = \frac{1}{V(\omega)} \int_{\omega} \frac{\rho_m C_{vm}}{\rho_M C_{vM}} \vartheta_m d\omega \end{array} \right.$$



- Up-scaling

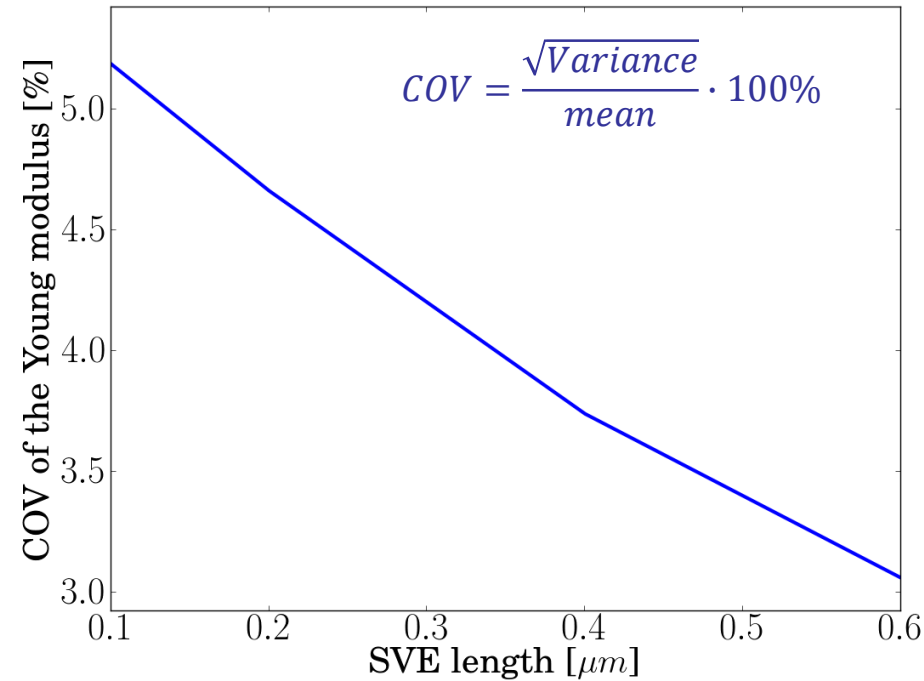
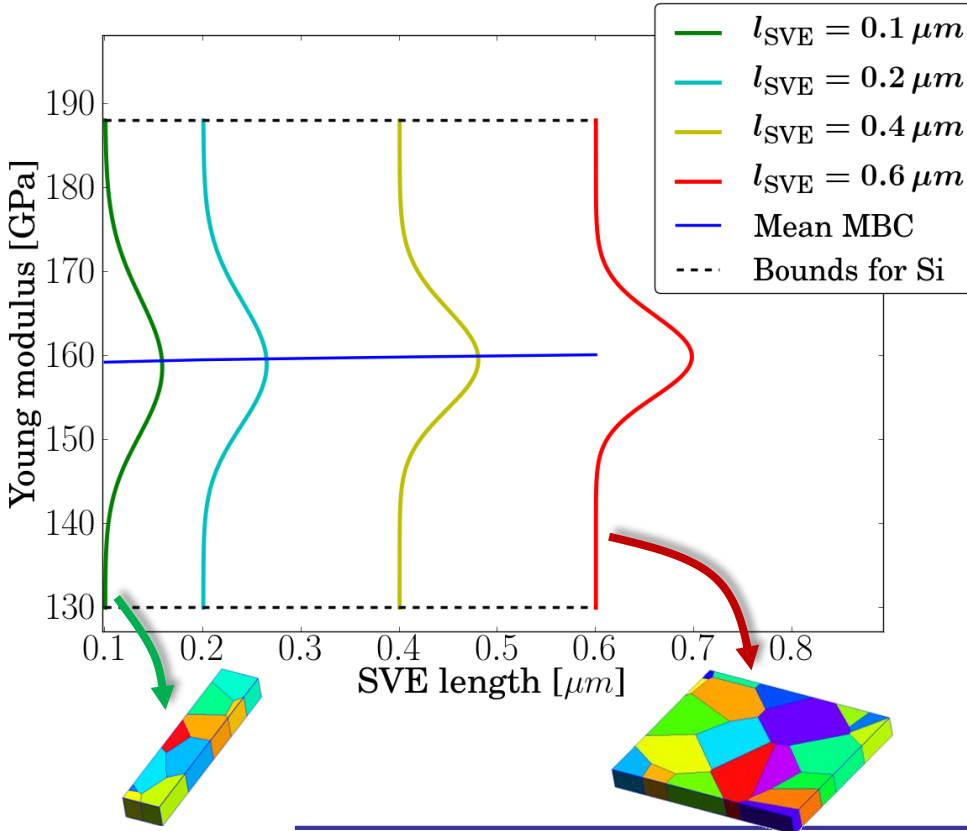
$$\left\{ \begin{array}{l} \sigma_M = \frac{1}{V(\omega)} \int_{\omega} \sigma_m d\omega \\ q_M = \frac{1}{V(\omega)} \int_{\omega} q_m d\omega \\ \rho_M C_{vM} = \frac{1}{V(\omega)} \int_{\omega} \rho_m C_{vm} dV \end{array} \right. \longrightarrow \left\{ \begin{array}{l} C_M = \frac{\partial \sigma_M}{\partial u_M \otimes \nabla_M} \quad \& \quad \alpha_M: C_M = - \frac{\partial \sigma_M}{\partial \vartheta_M} \\ \kappa_M = - \frac{\partial q_M}{\partial \nabla_M \vartheta_M} \end{array} \right.$$

- Consistency  $\longrightarrow$  Satisfied by periodic boundary conditions

# From the micro-scale to the meso-scale

- Distribution of the apparent meso-scale elasticity tensor  $\mathbb{C}_M$

➤ For large SVEs, the apparent tensor tends to the effective (and unique) one

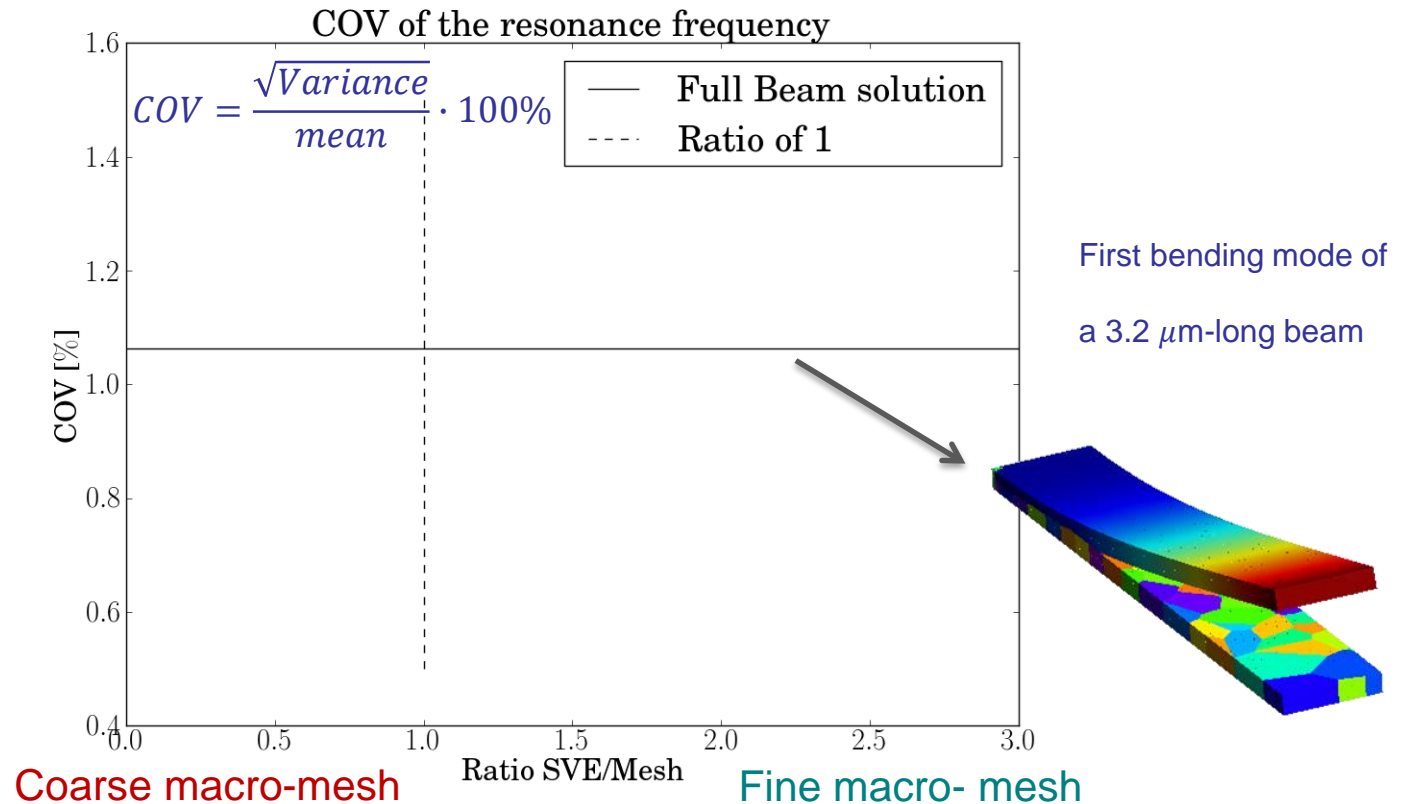
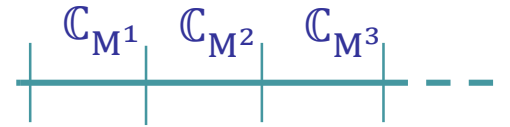


- The bounds do not depend on the SVE size but on the silicon elasticity tensor
- However, the larger the SVE, the lower the probability to be close to the bounds

# From the micro-scale to the meso-scale

- Use of the meso-scale distribution with macro-scale finite elements

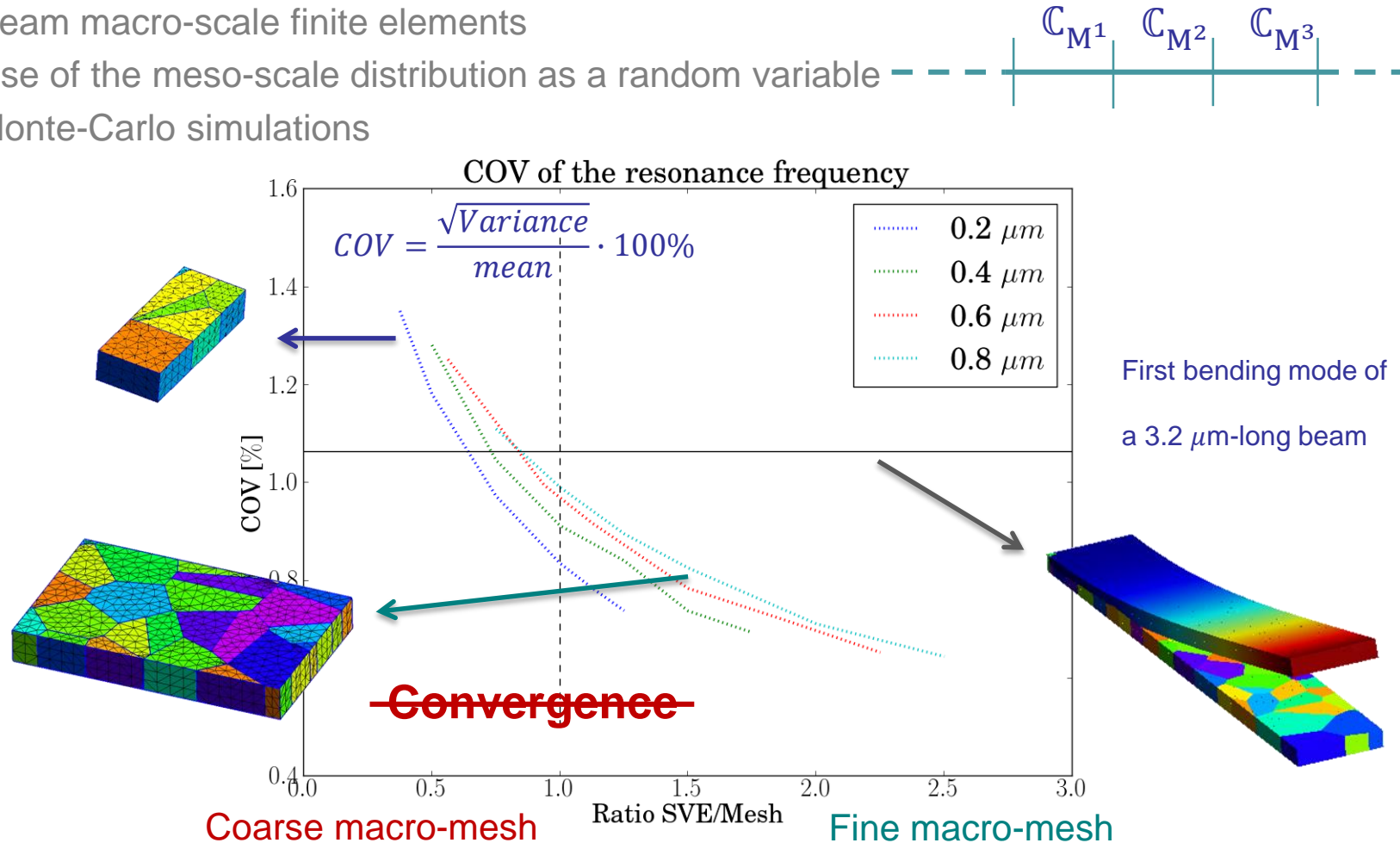
- Beam macro-scale finite elements
- Use of the meso-scale distribution as a random variable
- Monte-Carlo simulations



# From the micro-scale to the meso-scale

- Use of the meso-scale distribution with macro-scale finite elements

- Beam macro-scale finite elements
- Use of the meso-scale distribution as a random variable
- Monte-Carlo simulations



- No convergence: the macro-scale distribution (first resonance frequency) depends on SVE and mesh sizes

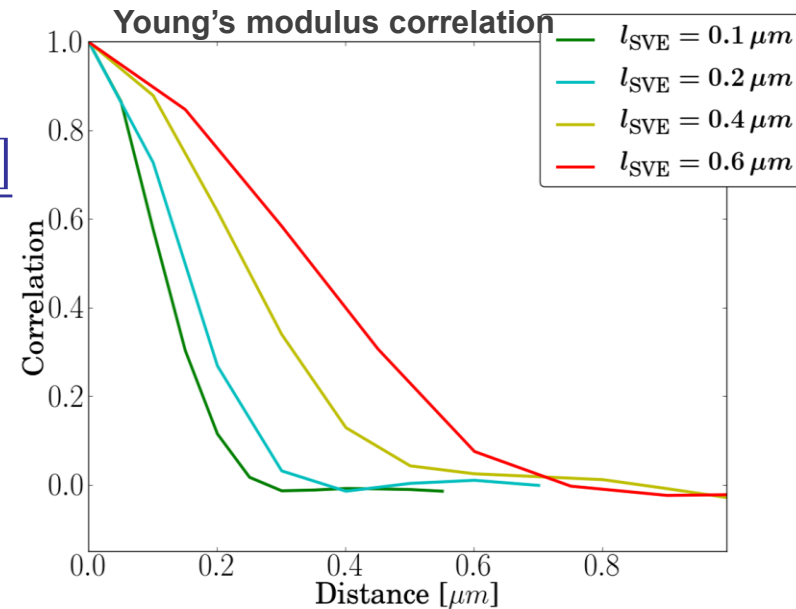
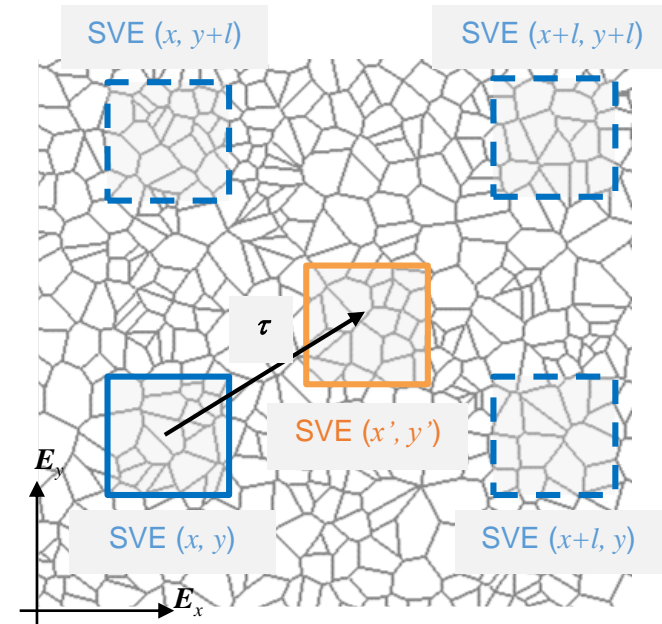


- Need for a meso-scale random field
  - Introduction of the (meso-scale) spatial correlation
    - Define large tessellations
    - SVEs extracted at different distances in each tessellation
  - Evaluate the spatial correlation between the components of the meso-scale material operators
  - For example, in 1D-elasticity
    - Young's modulus correlation

$$R_{E_x}(\tau) = \frac{\mathbb{E}[(E_x(x) - \mathbb{E}(E_x))(E_x(x + \tau) - \mathbb{E}(E_x))]}{\mathbb{E}[(E_x - \mathbb{E}(E_x))^2]}$$

- Correlation length

$$L_{E_x} = \frac{\int_{-\infty}^{\infty} R_{E_x}(\tau) d\tau}{R_{E_x}(0)}$$

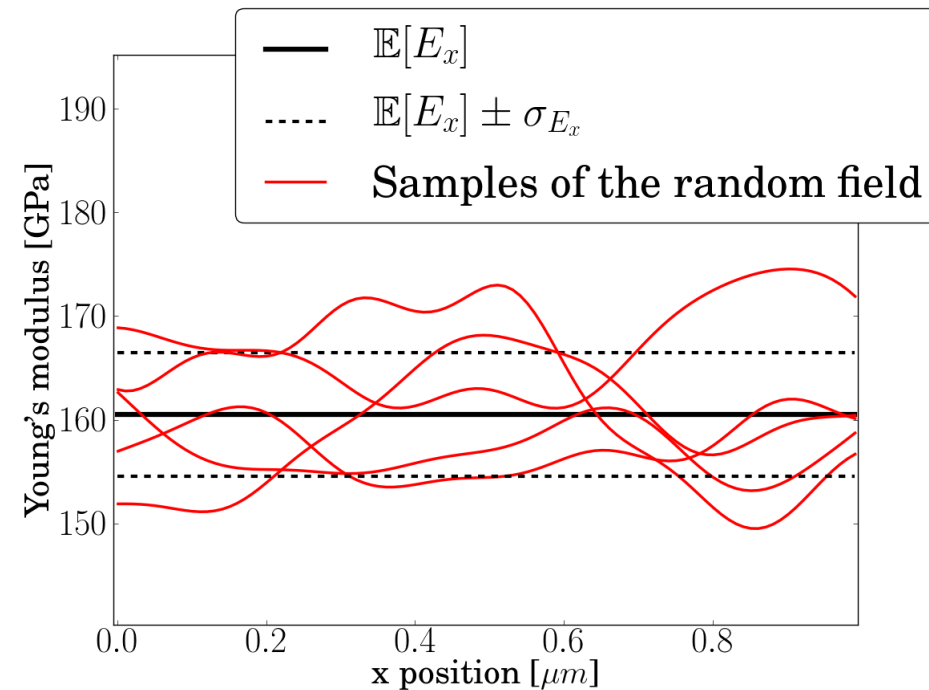
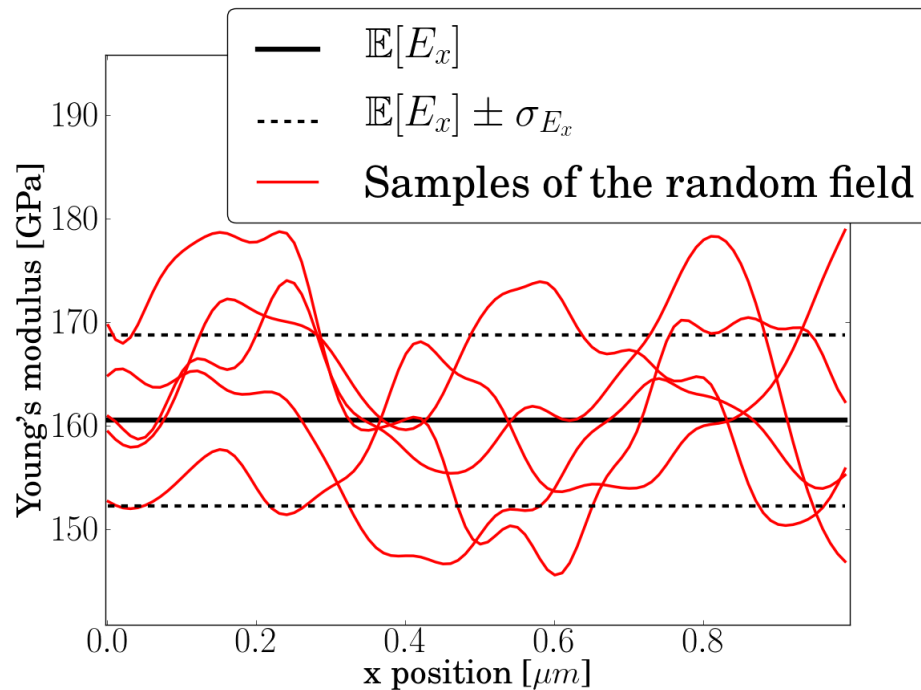


# From the micro-scale to the meso-scale

- Need for a meso-scale random field (2)
  - The meso-scale random field is characterized by the correlation length  $L_{E_x}$
  - The correlation length  $L_{E_x}$  depends on the SVE size

Random field with different SVEs sizes

$l_{\text{SVE}} = 0.1 \mu\text{m}$   $l_{\text{SVE}} = 0.4 \mu\text{m}$



# From the micro-scale to the meso-scale

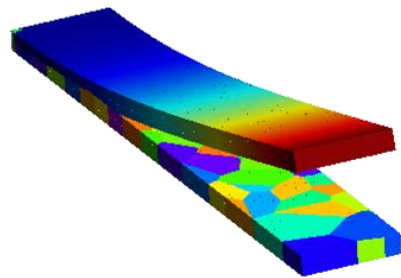
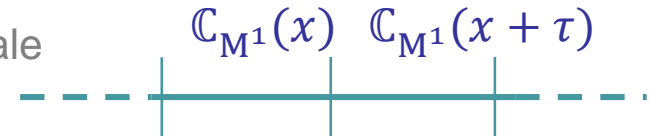
- Need for a meso-scale random field (3)

- Use of the meso-scale random field

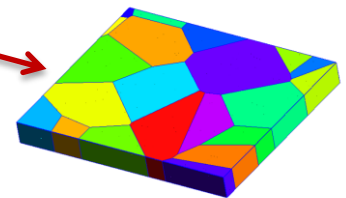
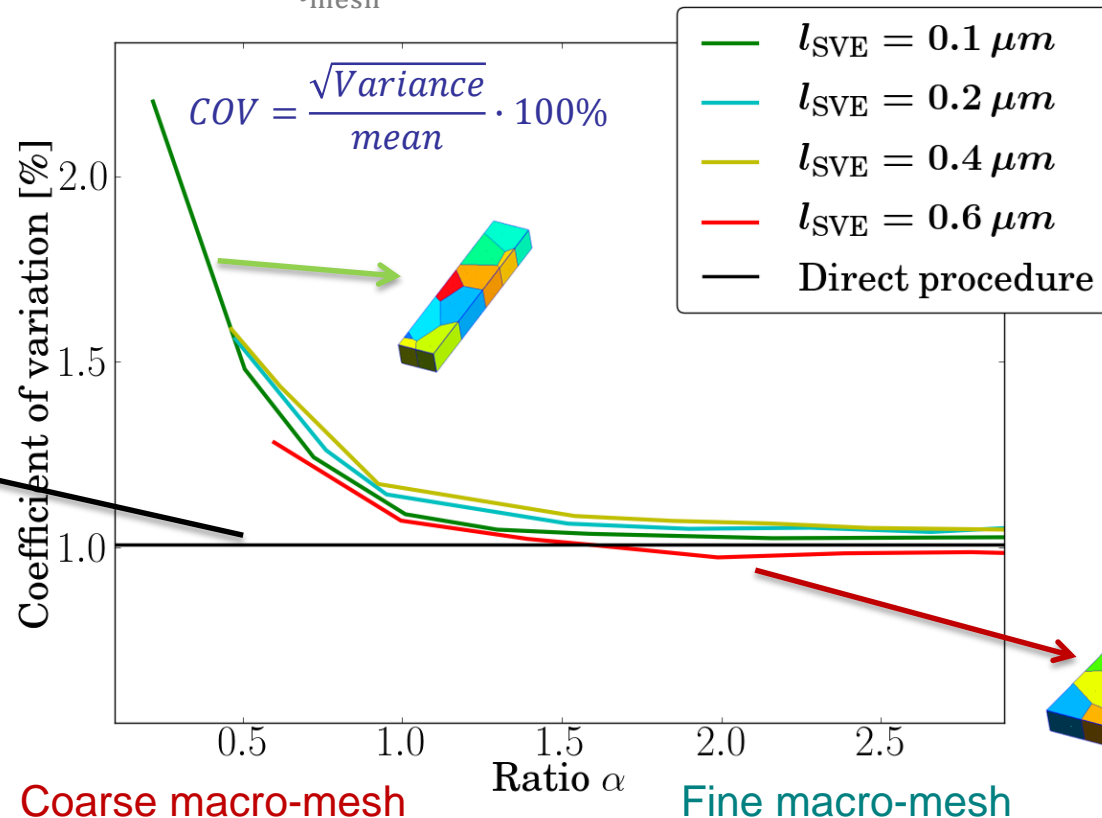
→ Monte-Carlo simulations at the macro-scale

- Macro-scale beam elements of size  $l_{\text{mesh}}$

- Convergence in terms of  $\alpha = \frac{L_{Ex}}{l_{\text{mesh}}}$



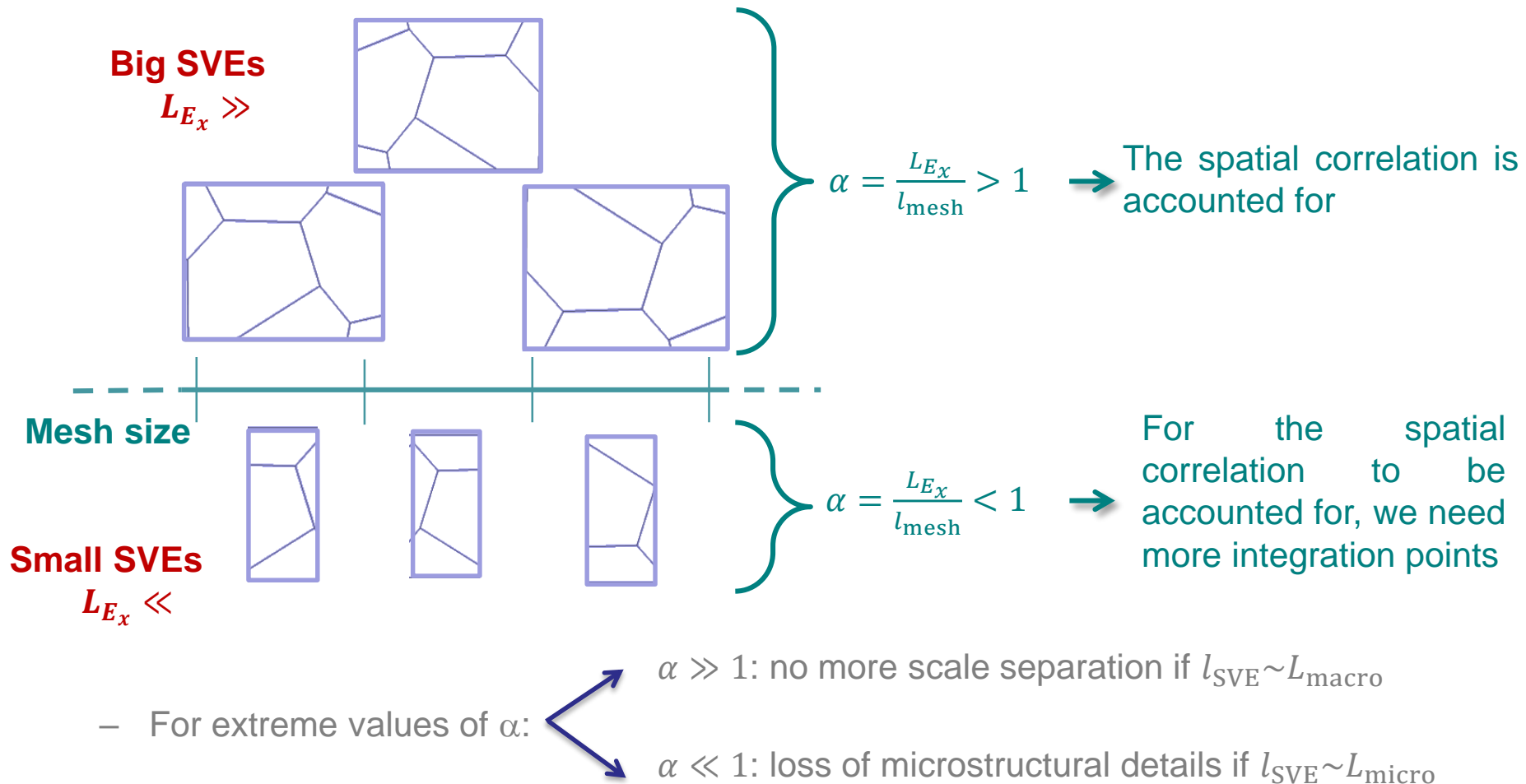
First bending mode of  
a 3.2  $\mu\text{m}$ -long beam



# From the micro-scale to the meso-scale

- Need for a meso-scale random field (3)

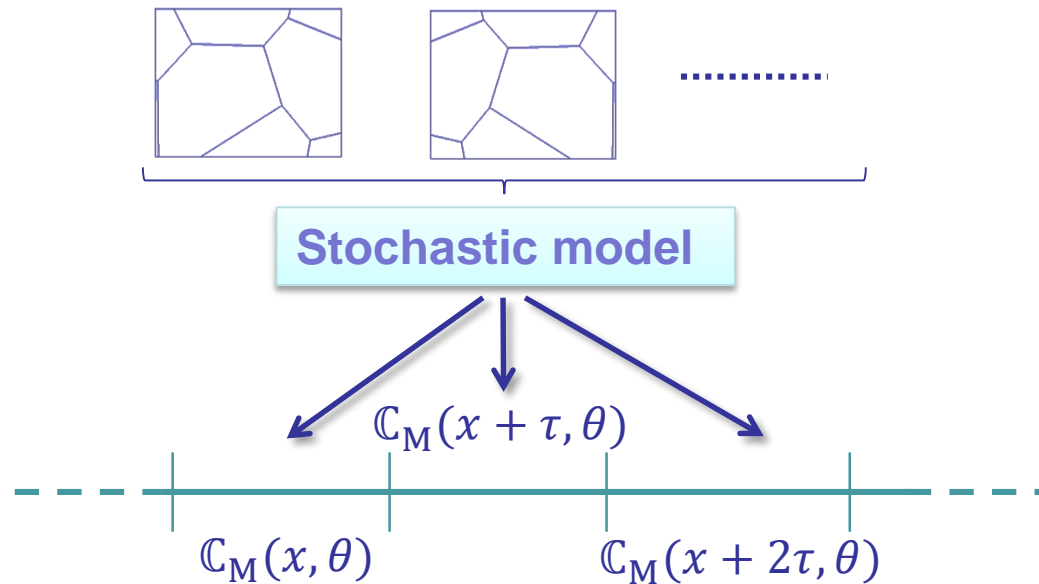
- Effect of the ratio  $\alpha = \frac{L_{Ex}}{l_{\text{mesh}}}$  ( Only one gauss point in one element)



- From the micro-scale to the meso-scale
  - Thermo-mechanical homogenization
  - Definition of Stochastic Volume Elements (SVEs) & Stochastic homogenization
  - Need for a meso-scale random field
- **The meso-scale random field**
  - Definition of the thermo-mechanical meso-scale random field
  - Stochastic model of the random field: Spectral generator & non-Gaussian mapping
- From the meso-scale to the macro-scale
  - 3-Scale approach verification
  - Application to extract the quality factor
- Accounting for roughness effect
  - From the micro-scale to the meso-scale
  - The meso-scale random field
  - From the meso-scale to the macro-scale

# The meso-scale random field

- Use of the meso-scale distribution with stochastic (macro-scale) finite elements
  - Use of the meso-scale random field
    - Monte-Carlo simulations at the macro-scale
  - BUT we do not want to evaluate the random field from the stochastic homogenization for each simulation → Meso-scale random field from a generator
    - Need for a stochastic model of meso-scale elasticity tensors



- Definition of the thermo-mechanical meso-scale random field

- Elasticity tensor  $\mathbb{C}_M(x, \theta)$  (matrix form  $\mathbf{C}_M$ ) & thermal conductivity  $\kappa_M$  are bounded
  - Ensure existence of their inverse
  - Define lower bounds  $\mathbb{C}_L$  and  $\kappa_L$  such that

$$\left\{ \begin{array}{ll} \boldsymbol{\varepsilon} : (\mathbb{C}_M - \mathbb{C}_L) : \boldsymbol{\varepsilon} > 0 & \forall \boldsymbol{\varepsilon} \\ \nabla \vartheta \cdot (\kappa_M - \kappa_L) \cdot \nabla \vartheta > 0 & \forall \nabla \vartheta \end{array} \right.$$

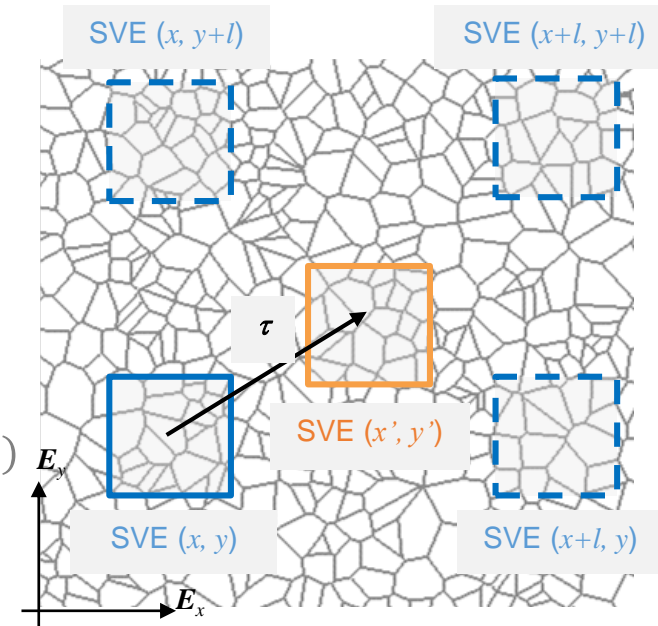
- Use a Cholesky decomposition when semi-positive definite matrices are required

$$\left\{ \begin{array}{l} \mathbf{C}_M(x, \theta) = \mathbf{C}_L + (\bar{\mathcal{A}} + \mathcal{A}'(x, \theta))^T (\bar{\mathcal{A}} + \mathcal{A}'(x, \theta)) \\ \kappa_M(x, \theta) = \kappa_L + (\bar{\mathcal{B}} + \mathcal{B}'(x, \theta))^T (\bar{\mathcal{B}} + \mathcal{B}'(x, \theta)) \\ \alpha_{M_{ij}}(x, \theta) = \bar{\nu}^{(t)} + \nu'^{(t)}(x, \theta) \end{array} \right.$$

- We define the homogenous zero-mean random field  $\nu'(x, \theta)$ , with as entries

- Elasticity tensor  $\mathcal{A}'(x, \theta) \Rightarrow \nu'^{(1)} \dots \nu'^{(21)}$ ,
- Heat conductivity tensor  $\mathcal{B}'(x, \theta) \Rightarrow \nu'^{(22)} \dots \nu'^{(27)}$
- Thermal expansion tensors  $\nu'^{(t)} \Rightarrow \nu'^{(28)} \dots \nu'^{(33)}$

- Characterization of the meso-scale random field
    - Generate large tessellation realizations
    - For each tessellation realization
      - Extract SVEs centered on  $\mathbf{x} + \boldsymbol{\tau}$
      - For each SVE evaluate  $\mathbb{C}_M(\mathbf{x} + \boldsymbol{\tau}), \kappa_M(\mathbf{x} + \boldsymbol{\tau}), \alpha_M(\mathbf{x} + \boldsymbol{\tau})$
    - From the set of realizations  $\mathbb{C}_M(\mathbf{x}, \boldsymbol{\theta}), \kappa_M(\mathbf{x}, \boldsymbol{\theta}), \alpha_M(\mathbf{x}, \boldsymbol{\theta})$ 
      - Evaluate the bounds  $\mathbb{C}_L$  and  $\kappa_L$
      - Apply the Cholesky decomposition  $\Rightarrow \mathcal{A}'(\mathbf{x}, \boldsymbol{\theta}), \mathcal{B}'(\mathbf{x}, \boldsymbol{\theta})$
      - Fill the 33 entries of the zero-mean homogenous field  $\boldsymbol{\nu}'(\mathbf{x}, \boldsymbol{\theta})$
    - Compute the auto-/cross-correlation matrix
- $$R_{\boldsymbol{\nu}'}^{(rs)}(\boldsymbol{\tau}) = \frac{\mathbb{E}[\boldsymbol{\nu}'^{(r)}(\mathbf{x})\boldsymbol{\nu}'^{(s)}(\mathbf{x} + \boldsymbol{\tau})]}{\sqrt{\mathbb{E}[(\boldsymbol{\nu}'^{(r)})^2]\mathbb{E}[(\boldsymbol{\nu}'^{(s)})^2]}}$$
- Generate zero-mean random field  $\boldsymbol{\nu}'(\mathbf{x}, \boldsymbol{\theta})$ 
    - Spectral generator & non-Gaussian mapping





- Stochastic model of the meso-scale random field: Spectral generator\*

- Start from the auto-/cross-covariance matrix

$$\tilde{R}_{\mathbf{v}'}^{(rs)}(\boldsymbol{\tau}) = \sigma_{\mathbf{v}'(r)} \sigma_{\mathbf{v}'(s)} R_{\mathbf{v}'}^{(rs)}(\boldsymbol{\tau}) = \mathbb{E} \left[ \left( \mathbf{v}'^{(r)}(\mathbf{x}) - \mathbb{E}(\mathbf{v}'^{(r)}) \right) \left( \mathbf{v}'^{(s)}(\mathbf{x} + \boldsymbol{\tau}) - \mathbb{E}(\mathbf{v}'^{(s)}) \right) \right]$$

- Evaluate the spectral density matrix from the periodized zero-padded matrix  $\tilde{R}_{\mathbf{v}'}^P(\boldsymbol{\tau})$

$$\mathbf{S}_{\mathbf{v}'}^{(rs)}[\boldsymbol{\omega}^{(m)}] = \sum_n \tilde{R}_{\mathbf{v}'}^P{}^{(rs)}[\boldsymbol{\tau}^{(n)}] e^{-2\pi i \boldsymbol{\tau}^{(n)} \cdot \boldsymbol{\omega}^{(m)}} \quad \& \quad \mathbf{S}_{\mathbf{v}'}[\boldsymbol{\omega}^{(m)}] = \mathbf{H}_{\mathbf{v}'}[\boldsymbol{\omega}^{(m)}] \mathbf{H}_{\mathbf{v}'}^*[\boldsymbol{\omega}^{(m)}]$$

- $\boldsymbol{\omega}$  gathers the discrete frequencies
- $\boldsymbol{\tau}$  gathers the discrete spatial locations

- Generate a Gaussian random field  $\mathbf{v}'(\mathbf{x}, \boldsymbol{\theta})$

$$\mathbf{v}'^{(r)}(\mathbf{x}, \boldsymbol{\theta}) = \sqrt{2\Delta\omega} \Re \left( \sum_s \sum_m \mathbf{H}_{\mathbf{v}'}^{(rs)}[\boldsymbol{\omega}^{(m)}] \eta^{(s,m)} e^{2\pi i (\mathbf{x} \cdot \boldsymbol{\omega}^{(m)} + \boldsymbol{\theta}^{(s,m)})} \right)$$

- $\boldsymbol{\eta}$  and  $\boldsymbol{\theta}$  are independent random variables

- Quid if a non-Gaussian distribution is sought?

\*Shinozuka, M., Deodatis, G., 1988

# The meso-scale random field

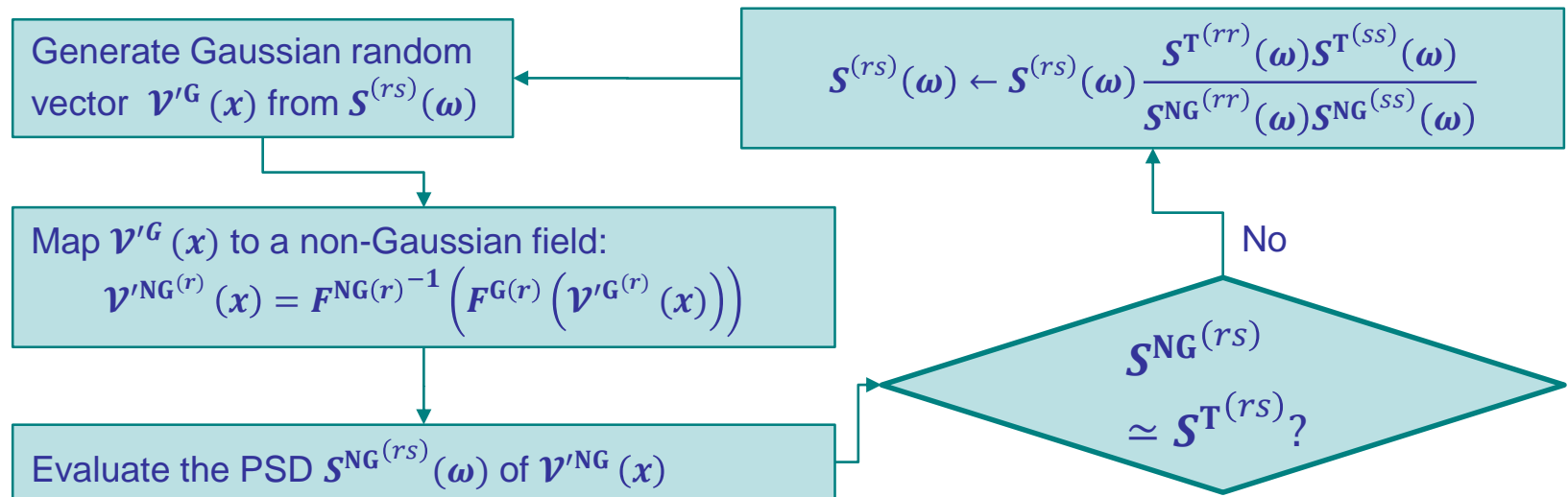
- Stochastic model of the meso-scale random field: non-Gaussian mapping\*
  - Start from micro-sampling of the stochastic homogenization

- The continuous form of the targeted PSD function

$$\mathcal{S}^{T(rs)}(\omega) = \Delta \tau \mathcal{S}_{\mathcal{V}'}^{(rs)}[\omega^{(m)}] = \Delta \tau \sum_n \tilde{R}_{\mathcal{V}'}^{\text{P}(rs)}[\tau^{(n)}] e^{-2\pi i \tau^{(n)} \cdot \omega^{(m)}}$$

- The targeted marginal distribution density function  $F^{\text{NG}(r)}$  of the random variable  $\mathcal{V}'^{(r)}$
- A marginal Gaussian distribution  $F^{\text{G}(r)}$  of zero-mean and targeted variance  $\sigma_{\mathcal{V}'^{(r)}}$

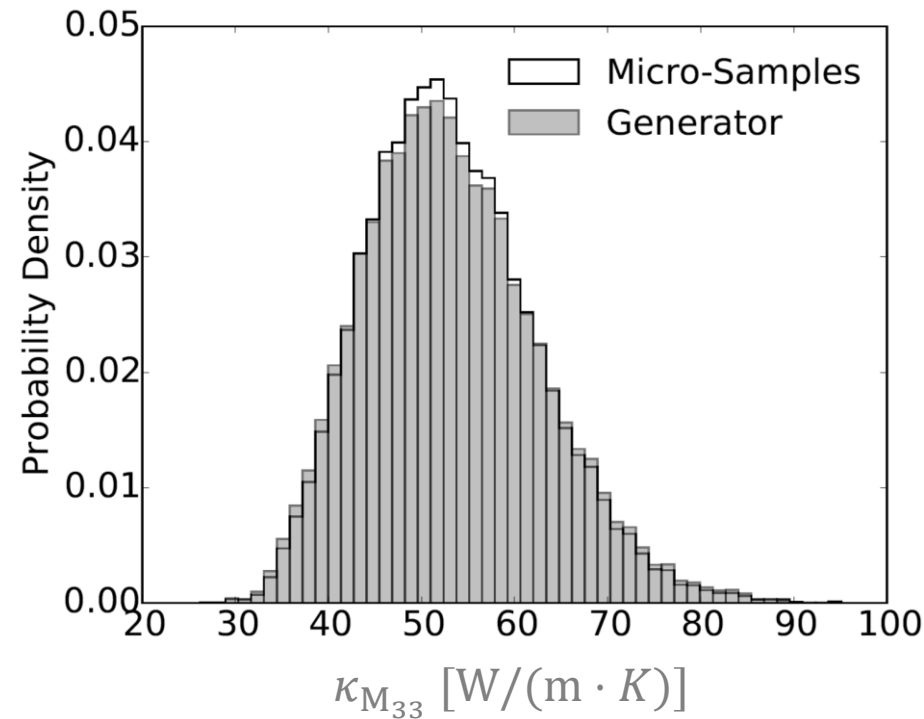
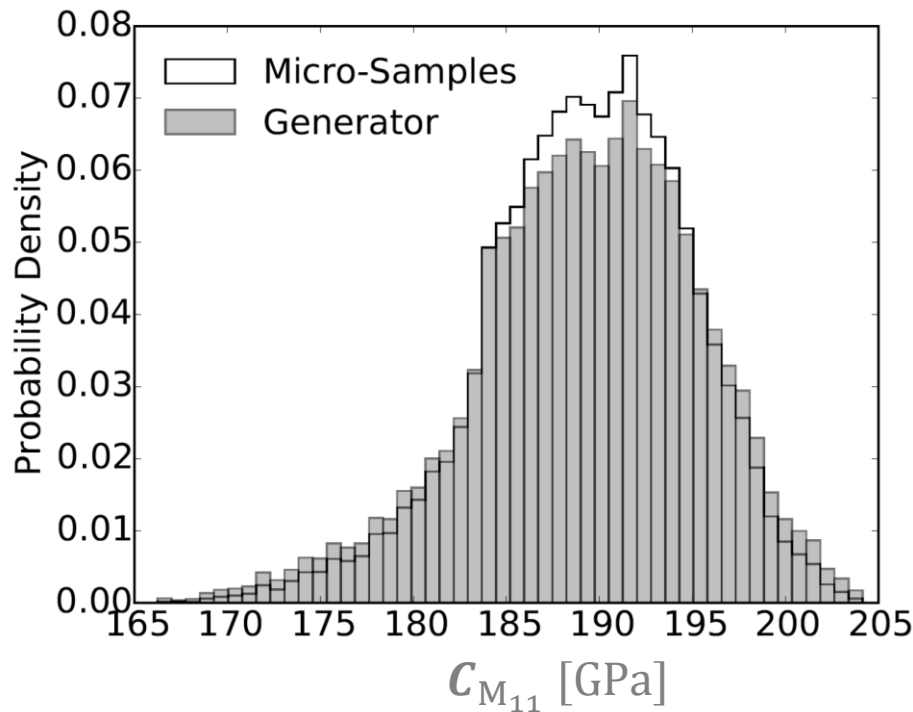
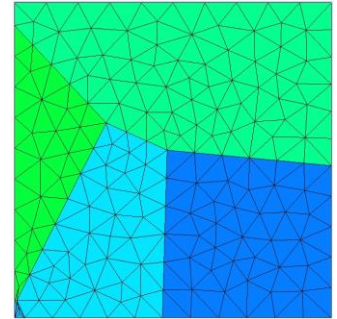
- Iterate



\*Deodatis, G., Micaletti, R., 2001

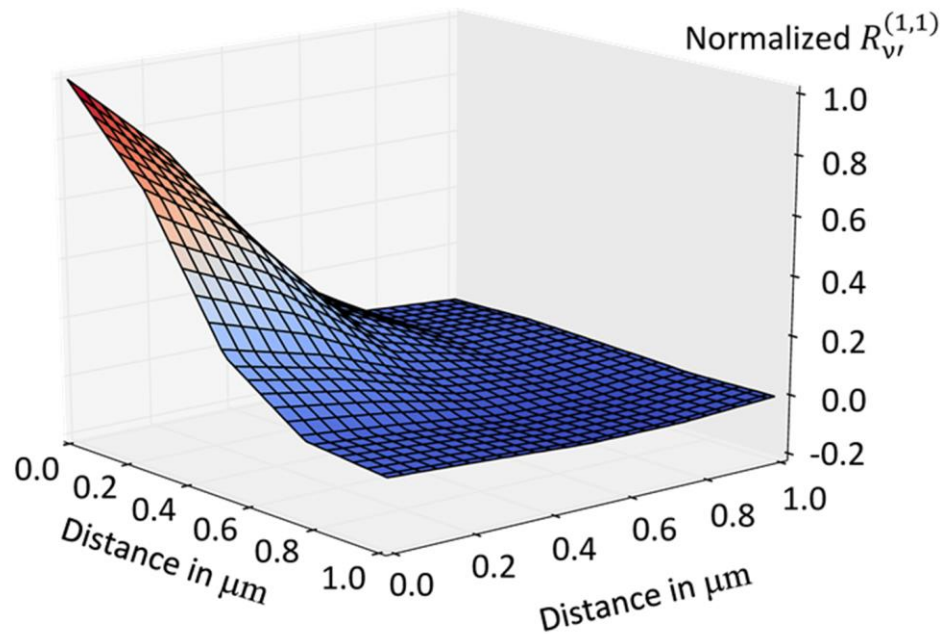
# The meso-scale random field

- Polysilicon film deposited at 610 °C
  - SVE size of  $0.5 \times 0.5 \mu\text{m}^2$
  - Comparison between micro-samples and generated field PDFs

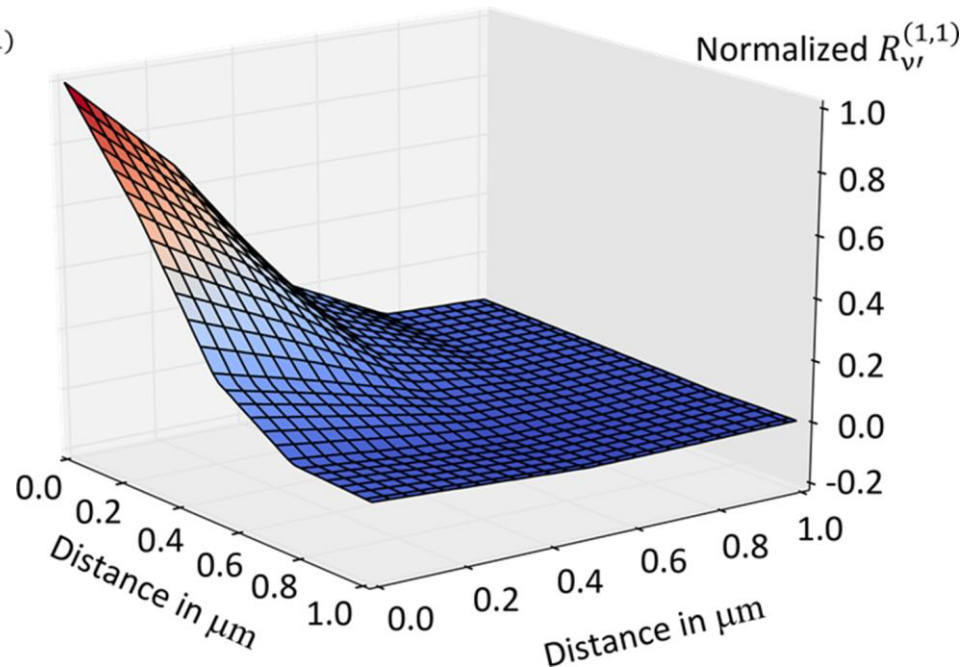


# The meso-scale random field

- Polysilicon film deposited at 610 °C (2)
  - Comparison between micro-samples and generated field cross-correlations



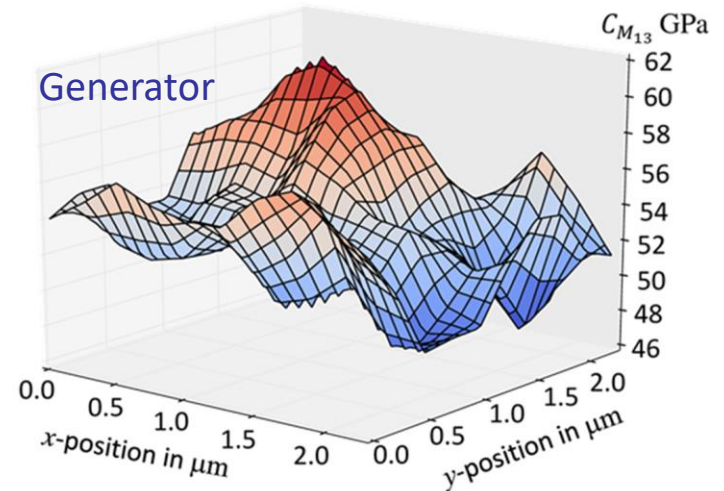
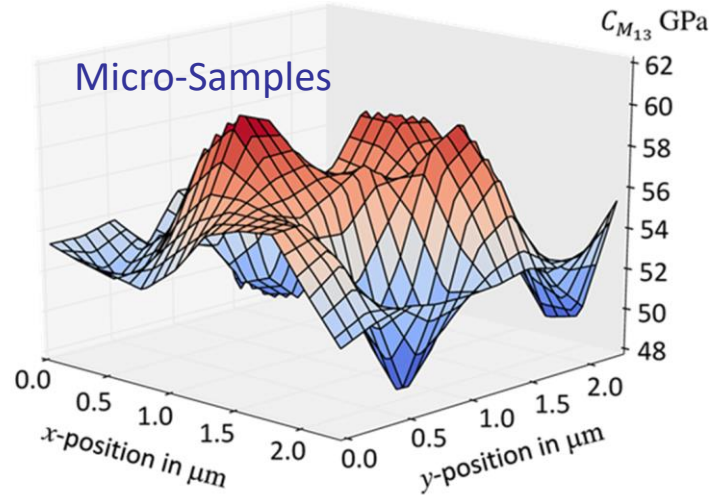
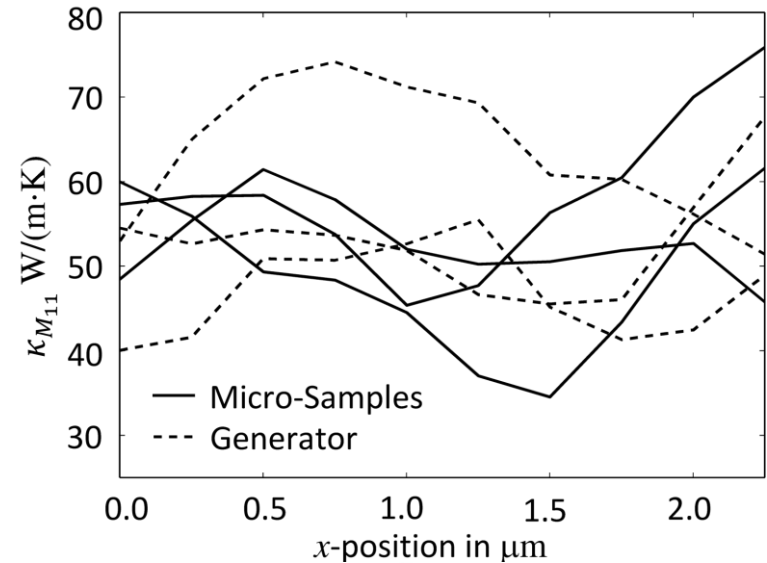
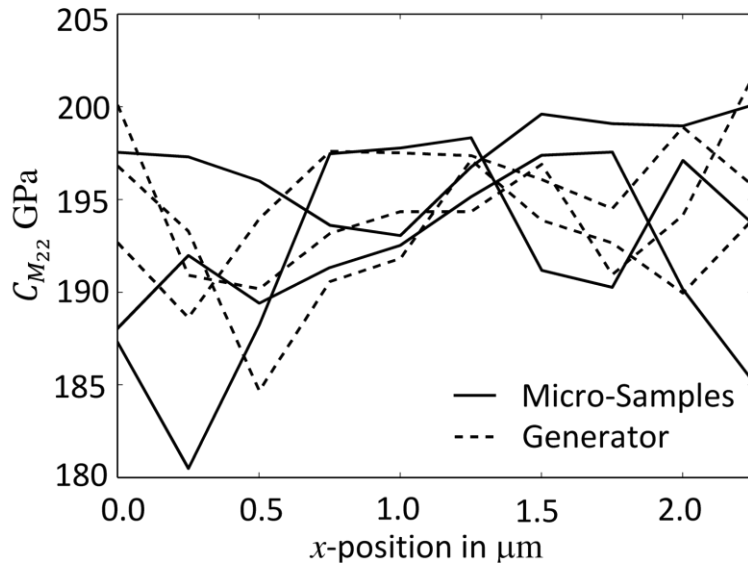
Micro-Samples



Generator

# The meso-scale random field

- Polysilicon film deposited at 610 °C (3)
  - Comparison between micro-samples and generated random field realizations



- From the micro-scale to the meso-scale
  - Thermo-mechanical homogenization
  - Definition of Stochastic Volume Elements (SVEs) & Stochastic homogenization
  - Need for a meso-scale random field
- The meso-scale random field
  - Definition of the thermo-mechanical meso-scale random field
  - Stochastic model of the random field: Spectral generator & non-Gaussian mapping
- **From the meso-scale to the macro-scale**
  - 3-Scale approach verification
  - Application to extract the quality factor
- Accounting for roughness effect
  - From the micro-scale to the meso-scale
  - The meso-scale random field
  - From the meso-scale to the macro-scale

# From the meso-scale to the macro-scale

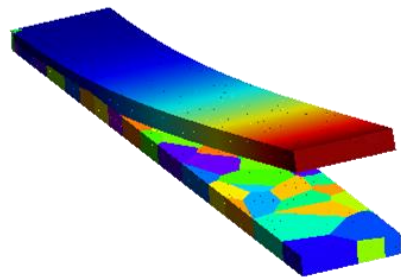
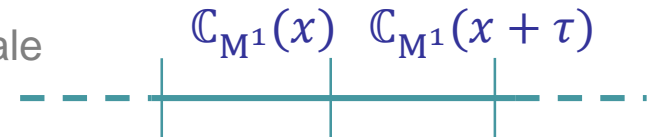
- 3-Scale approach verification with direct Monte-Carlo simulations

- Use of the meso-scale random field

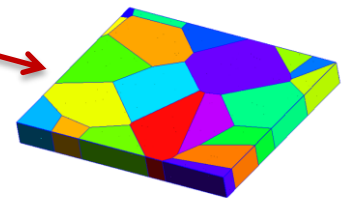
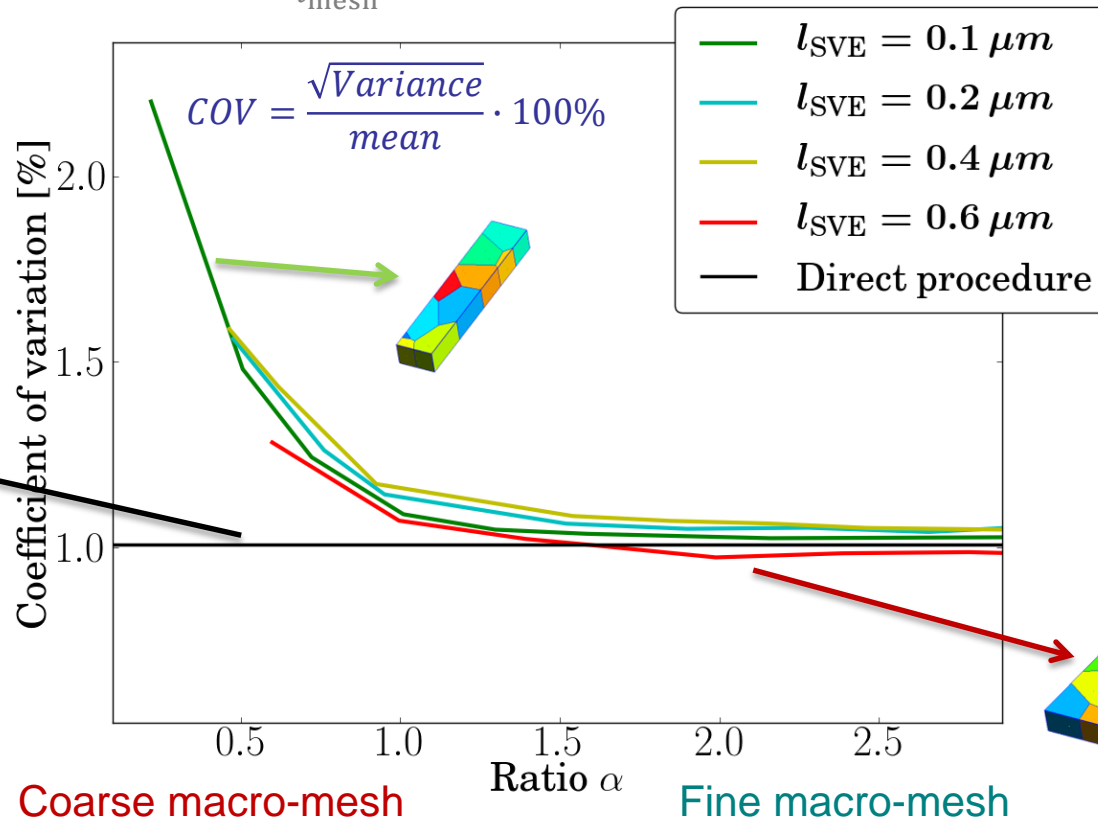
→ Monte-Carlo simulations at the macro-scale

- Macro-scale beam elements of size  $l_{\text{mesh}}$

- Convergence in terms of  $\alpha = \frac{l_{Ex}}{l_{\text{mesh}}}$

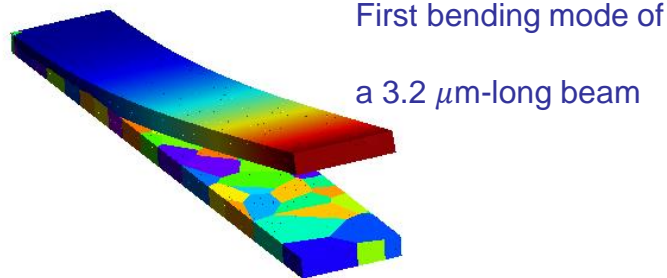


First bending mode of  
a 3.2  $\mu\text{m}$ -long beam

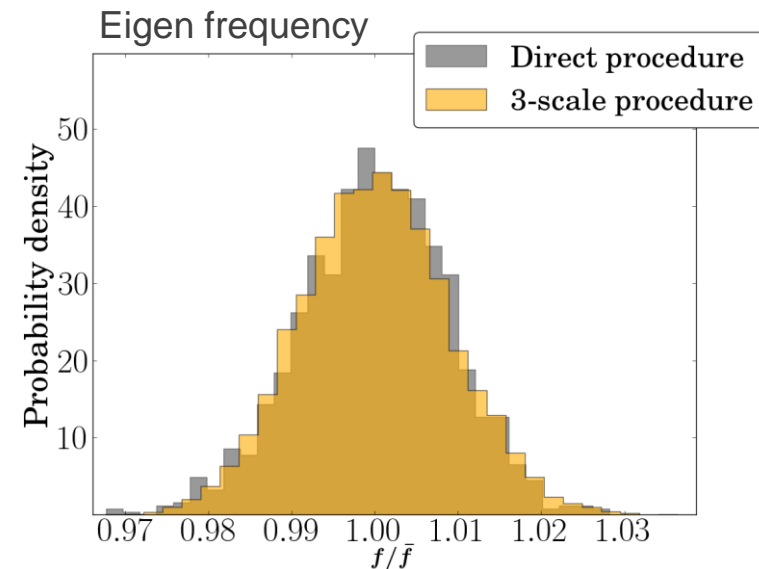
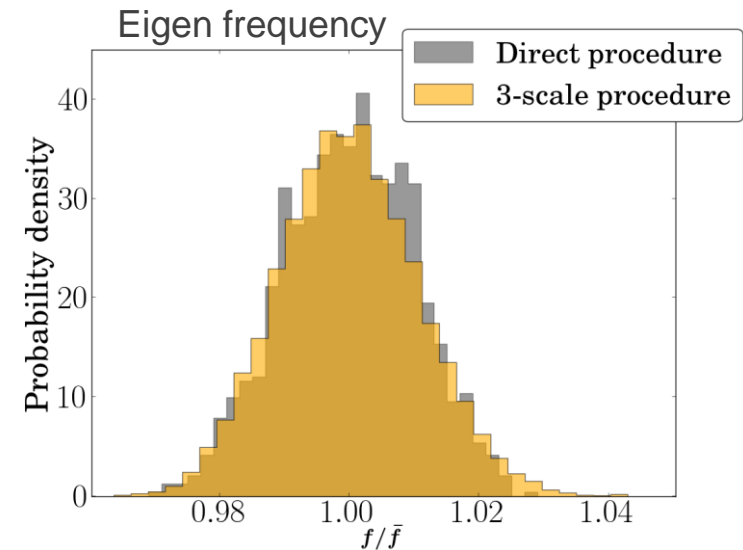
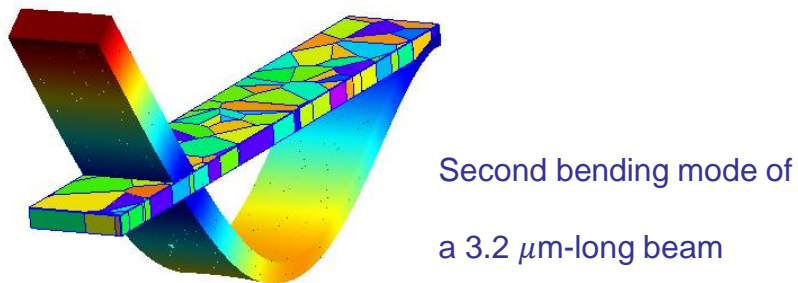


# From the meso-scale to the macro-scale

- 3-Scale approach verification ( $\alpha \sim 2$ ) with direct Monte-Carlo simulations
  - First bending mode



- Second bending mode

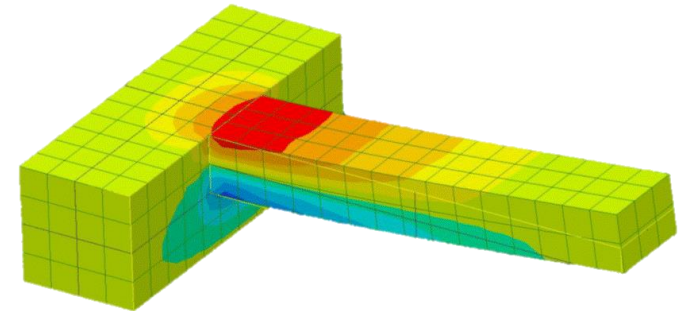




- Quality factor

- Micro-resonators

- Temperature changes with compression/traction
    - Energy dissipation



- Eigen values problem

- Governing equations

$$\begin{bmatrix} \mathbf{M} & \mathbf{0} \\ \mathbf{0} & \mathbf{0} \end{bmatrix} \begin{bmatrix} \ddot{\mathbf{u}} \\ \ddot{\boldsymbol{\vartheta}} \end{bmatrix} + \begin{bmatrix} \mathbf{0} & \mathbf{0} \\ \mathbf{D}_{u\vartheta}(\boldsymbol{\theta}) & \mathbf{D}_{\vartheta\vartheta} \end{bmatrix} \begin{bmatrix} \dot{\mathbf{u}} \\ \dot{\boldsymbol{\vartheta}} \end{bmatrix} + \begin{bmatrix} \mathbf{K}_{uu}(\boldsymbol{\theta}) & \mathbf{K}_{u\vartheta}(\boldsymbol{\theta}) \\ \mathbf{0} & \mathbf{K}_{\vartheta\vartheta}(\boldsymbol{\theta}) \end{bmatrix} \begin{bmatrix} \mathbf{u} \\ \boldsymbol{\vartheta} \end{bmatrix} = \begin{bmatrix} \mathbf{F}_u \\ \mathbf{F}_{\vartheta} \end{bmatrix}$$

- Free vibrating problem

$$\begin{bmatrix} \mathbf{u}(t) \\ \boldsymbol{\vartheta}(t) \end{bmatrix} = \begin{bmatrix} \mathbf{u}_0 \\ \boldsymbol{\vartheta}_0 \end{bmatrix} e^{i\omega t}$$

$$\hookrightarrow \begin{bmatrix} -\mathbf{K}_{uu}(\boldsymbol{\theta}) & -\mathbf{K}_{u\vartheta}(\boldsymbol{\theta}) & \mathbf{0} \\ \mathbf{0} & -\mathbf{K}_{\vartheta\vartheta}(\boldsymbol{\theta}) & \mathbf{0} \\ \mathbf{0} & \mathbf{0} & \mathbf{I} \end{bmatrix} \begin{bmatrix} \mathbf{u} \\ \boldsymbol{\vartheta} \\ \dot{\mathbf{u}} \end{bmatrix} = i\omega \begin{bmatrix} \mathbf{0} & \mathbf{0} & \mathbf{M} \\ \mathbf{D}_{\vartheta u}(\boldsymbol{\theta}) & \mathbf{D}_{\vartheta\vartheta} & \mathbf{0} \\ \mathbf{I} & \mathbf{0} & \mathbf{0} \end{bmatrix} \begin{bmatrix} \mathbf{u} \\ \boldsymbol{\vartheta} \\ \dot{\mathbf{u}} \end{bmatrix}$$

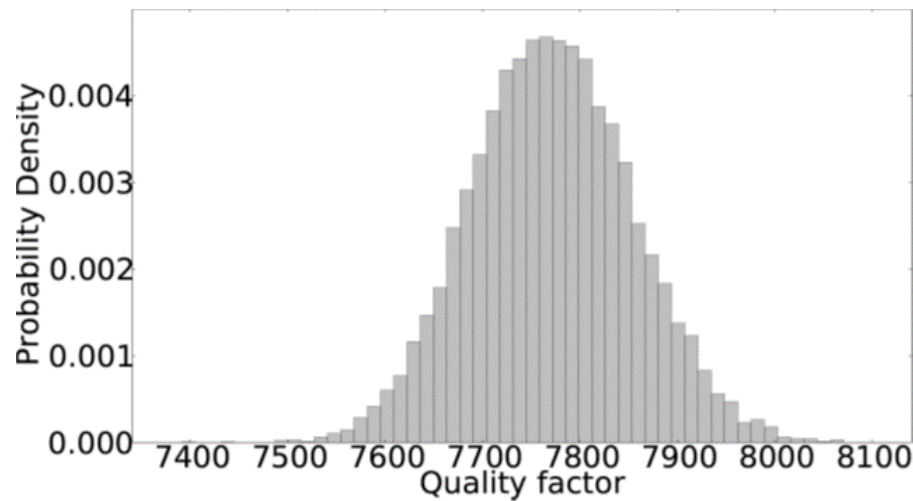
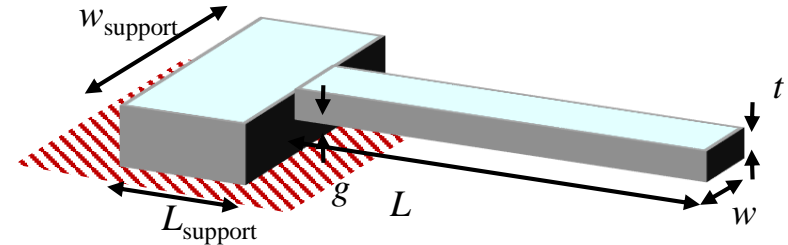
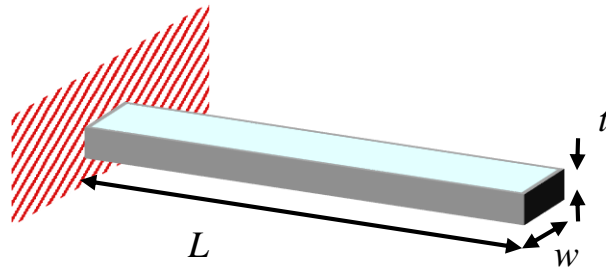
- Quality factor

- From the dissipated energy per cycle

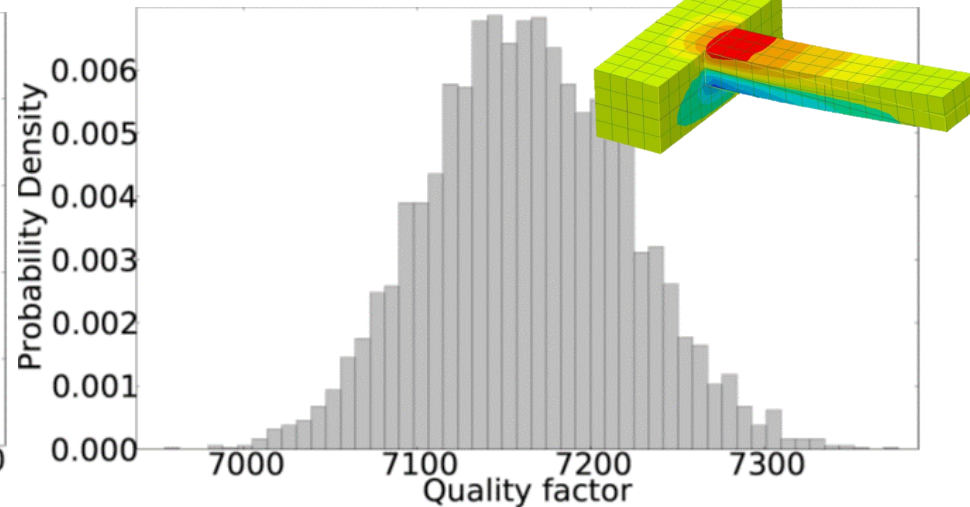
$$Q^{-1} = \frac{2|\Im\omega|}{\sqrt{(\Im\omega)^2 + (\Re\omega)^2}}$$

# From the meso-scale to the macro-scale

- Application of the 3-Scale method to extract the quality factor distribution
  - 3D models readily available
  - The effect of the anchor can be studied



$15 \times 3 \times 2 \mu\text{m}^3$ -beam,  
deposited at 610 °C

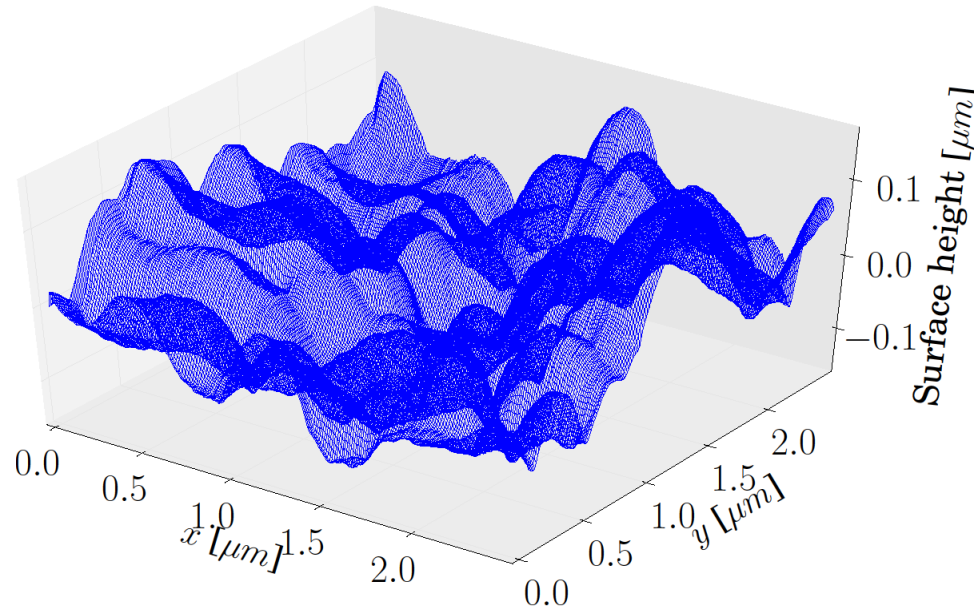


$15 \times 3 \times 2 \mu\text{m}^3$ -beam & anchor,  
deposited at 610 °C

- From the micro-scale to the meso-scale
  - Thermo-mechanical homogenization
  - Definition of Stochastic Volume Elements (SVEs) & Stochastic homogenization
  - Need for a meso-scale random field
- The meso-scale random field
  - Definition of the thermo-mechanical meso-scale random field
  - Stochastic model of the random field: Spectral generator & non-Gaussian mapping
- From the meso-scale to the macro-scale
  - 3-Scale approach verification
  - Application to extract the quality factor
- Accounting for roughness effect
  - From the micro-scale to the meso-scale
  - The meso-scale random field
  - From the meso-scale to the macro-scale

# Accounting for roughness effect

- Surface topology: asperity distribution
  - Upper surface topology by AFM (Atomic Force Microscope) measurements on 2  $\mu\text{m}$ -thick poly-silicon films



Deposition temperature [ $^{\circ}\text{C}$ ]	580	610	630	650
Std deviation [nm]	35.6	60.3	90.7	88.3

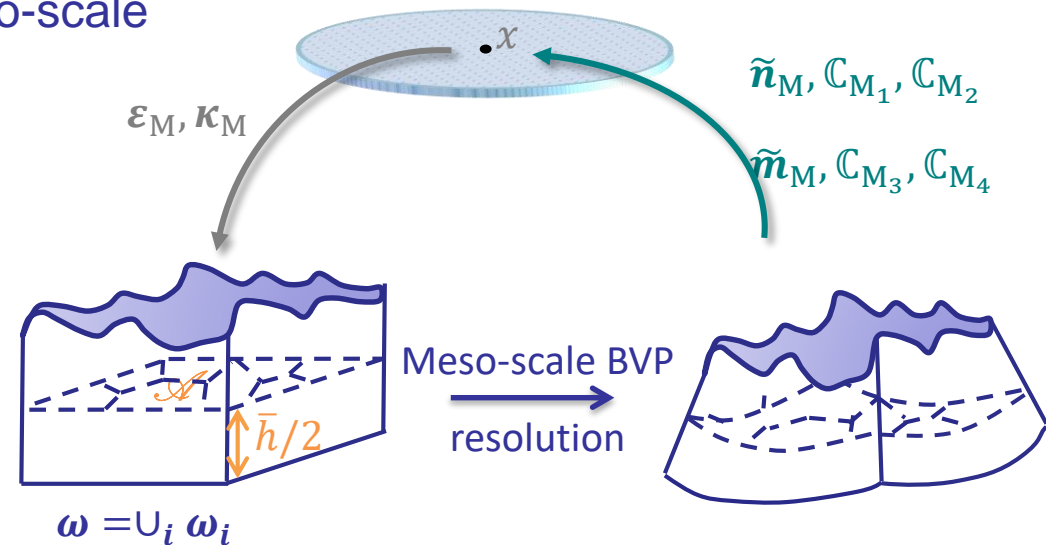
AFM data provided by IMT Bucharest, Rodica Voicu, Angela Baracu, Raluca Muller

# Accounting for roughness effect

- From the micro-scale to the meso-scale

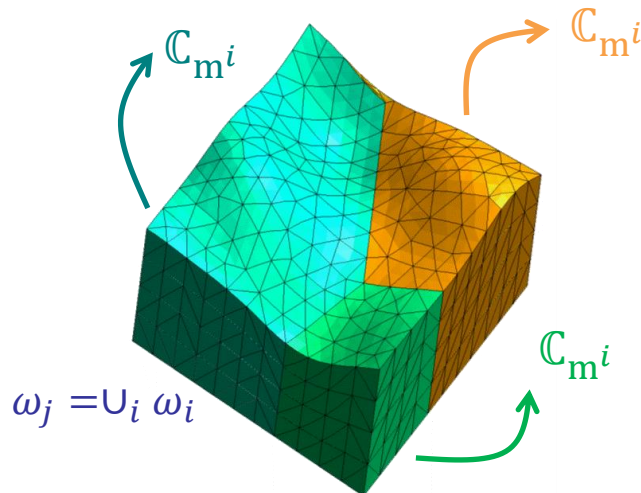
- Second-order homogenization

$$\begin{cases} \tilde{\mathbf{n}}_M = \mathbb{C}_{M_1} : \boldsymbol{\varepsilon}_M + \mathbb{C}_{M_2} : \boldsymbol{\kappa}_M \\ \tilde{\mathbf{m}}_M = \mathbb{C}_{M_3} : \boldsymbol{\varepsilon}_M + \mathbb{C}_{M_4} : \boldsymbol{\kappa}_M \end{cases}$$



- Stochastic homogenization

- Several SVE realizations
    - For each SVE  $\boldsymbol{\omega}_j = \mathbf{U}_i \boldsymbol{\omega}_i$
    - The density per unit area is now non-constant



$$\mathbb{C}_{m^i} \forall i$$

Computational homogenization

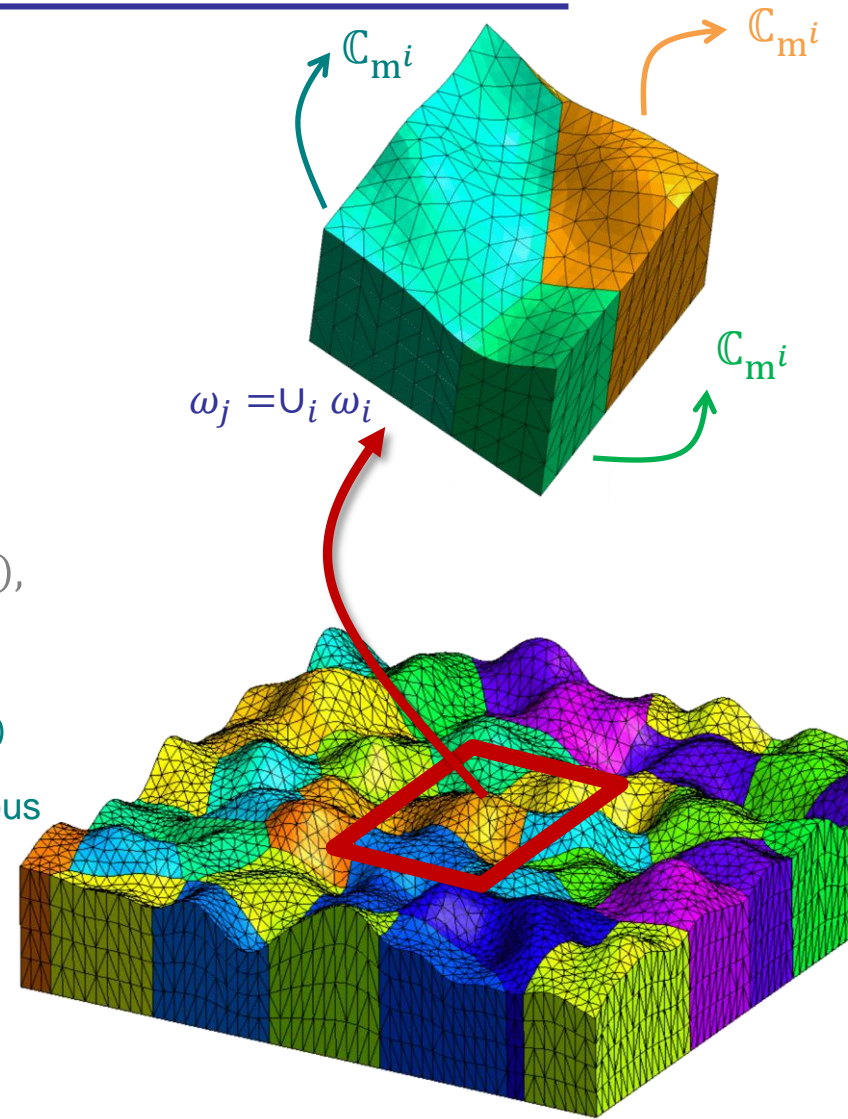
$$\mathbb{C}_{M_1^j}, \mathbb{C}_{M_2^j}, \mathbb{C}_{M_3^j}, \mathbb{C}_{M_4^j} \longrightarrow \mathbf{U}_{M^j}$$

$$\bar{\rho}_{M^j}$$

Samples of the meso-scale homogenized elasticity matrix  $\mathbf{U}_M$  & density  $\bar{\rho}_M$

- The meso-scale random field
  - Generate large tessellation realizations
  - For each tessellation realization
    - Extract SVEs centred at  $\mathbf{x} + \boldsymbol{\tau}$
    - For each SVE evaluate  $U_M(\mathbf{x} + \boldsymbol{\tau}), \bar{\rho}_M(\mathbf{x} + \boldsymbol{\tau})$
  - From the set of realizations  $U_M(\mathbf{x}, \boldsymbol{\theta}), \bar{\rho}_M(\mathbf{x}, \boldsymbol{\theta})$ ,
    - Evaluate the bounds  $U_L$  and  $\bar{\rho}_L$
    - Apply the Cholesky decomposition  $\Rightarrow \mathcal{A}'(\mathbf{x}, \boldsymbol{\theta})$
    - Fill the 22 entries of the zero-mean homogenous field  $\mathcal{V}'(\mathbf{x}, \boldsymbol{\theta})$
  - Compute the auto-/cross-correlation matrix

$$R_{\mathcal{V}'}^{(rs)}(\boldsymbol{\tau}) = \frac{\mathbb{E}[\mathcal{V}'^{(r)}(\mathbf{x})\mathcal{V}'^{(s)}(\mathbf{x} + \boldsymbol{\tau})]}{\sqrt{\mathbb{E}[(\mathcal{V}'^{(r)})^2]\mathbb{E}[(\mathcal{V}'^{(s)})^2]}}$$



# Accounting for roughness effect

- From the meso-scale to the macro-scale
  - Cantilever of  $8 \times 3 \times t \mu\text{m}^3$  deposited at  $610^\circ\text{C}$

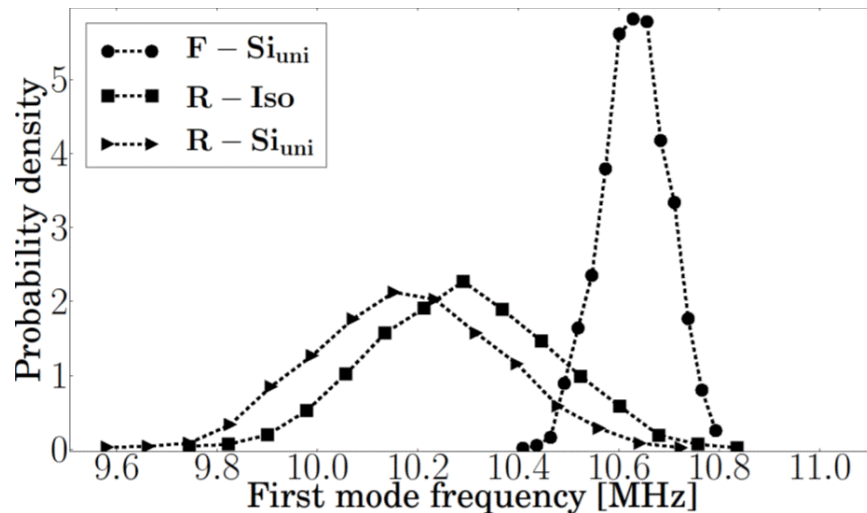
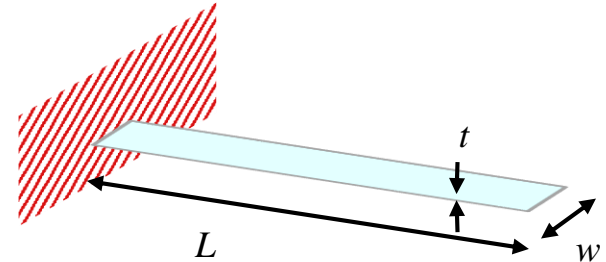
Flat SVEs (no roughness) - F

Rough SVEs ( Polysilicon film deposited at  $610^\circ\text{C}$  ) - R

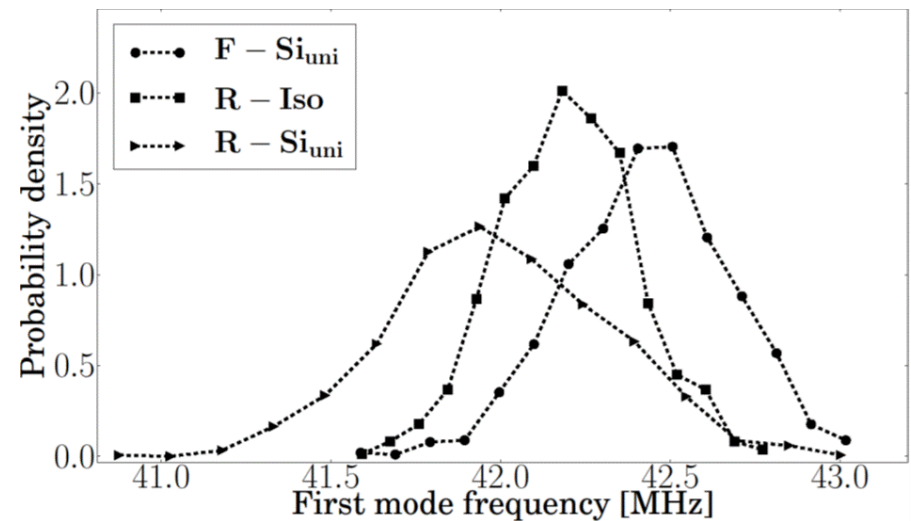
Grain orientation following XRD measurements –  $\text{Si}_{\text{pref}}$

Grain orientation uniformly distributed –  $\text{Si}_{\text{uni}}$

Reference isotropic material – Iso



Roughness effect is the most important  
for  $8 \times 3 \times 0.5 \mu\text{m}^3$  cantilevers



Roughness effect is of same importance as  
orientation for  $8 \times 3 \times 2 \mu\text{m}^3$  cantilevers



- Efficient stochastic multi-scale method
  - Micro-structure based on experimental measurements
  - Computational efficiency relies on the meso-scale random field generator
  - Used to study probabilistic behaviors
- Perspectives
  - Other material systems
  - Non-linear behaviors
  - Non-homogenous random fields



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Thank you for your attention !

- Governing equations

- Thermo-mechanics

- Linear balance  $\rho \ddot{\mathbf{u}} - \nabla \cdot \boldsymbol{\sigma} - \rho \mathbf{b} = 0$

- Clausius-Duhem inequality in terms of volume entropy rate  $\dot{S} = -\frac{\nabla \cdot \mathbf{q}}{T}$

- Helmholtz free energy

$$\left\{ \begin{array}{l} \mathcal{F}(\boldsymbol{\varepsilon}, T) = \mathcal{F}_0(T) - \boldsymbol{\varepsilon} : \frac{\partial^2 \psi}{\partial \boldsymbol{\varepsilon} \partial \boldsymbol{\varepsilon}} : \boldsymbol{\alpha} (T - T_0) + \psi(\boldsymbol{\varepsilon}) \\ \boldsymbol{\sigma} = \left( \frac{\partial \mathcal{F}}{\partial \boldsymbol{\varepsilon}} \right)_T, \quad S = \left( \frac{\partial \mathcal{F}}{\partial T} \right)_{\boldsymbol{\varepsilon}} \quad \& \quad \left( \frac{\partial^2 \mathcal{F}_0}{\partial T \partial T} \right) = \rho C_v \end{array} \right.$$

- Strong form in terms of the displacements  $\mathbf{u}$  and temperature change  $\vartheta$  (linear elasticity)

$$\hookrightarrow \left\{ \begin{array}{l} \rho \ddot{\mathbf{u}} - \nabla \cdot (\mathbb{C} : \dot{\boldsymbol{\varepsilon}} - \mathbb{C} : \boldsymbol{\alpha} \dot{\vartheta}) - \rho \mathbf{b} = 0 \\ \rho C_v \dot{\vartheta} + T_0 \boldsymbol{\alpha} : \mathbb{C} : \dot{\boldsymbol{\varepsilon}} - \nabla \cdot (\boldsymbol{\kappa} \nabla \vartheta) = 0 \end{array} \right.$$

- Finite element discretization

$$\hookrightarrow \begin{bmatrix} \mathbf{M}(\rho) & \mathbf{0} \\ \mathbf{0} & \mathbf{0} \end{bmatrix} \begin{bmatrix} \ddot{\mathbf{u}} \\ \ddot{\vartheta} \end{bmatrix} + \begin{bmatrix} \mathbf{0} & \mathbf{0} \\ \mathbf{D}_{\vartheta \mathbf{u}}(\boldsymbol{\alpha}, \mathbb{C}) & \mathbf{D}_{\vartheta \vartheta}(\rho C_v) \end{bmatrix} \begin{bmatrix} \dot{\mathbf{u}} \\ \dot{\vartheta} \end{bmatrix} + \begin{bmatrix} \mathbf{K}_{\mathbf{u}\mathbf{u}}(\mathbb{C}) & \mathbf{K}_{\mathbf{u}\vartheta}(\boldsymbol{\alpha}, \mathbb{C}) \\ \mathbf{0} & \mathbf{K}_{\vartheta\vartheta}(\boldsymbol{\kappa}) \end{bmatrix} \begin{bmatrix} \mathbf{u} \\ \vartheta \end{bmatrix} = \begin{bmatrix} \mathbf{F}_{\mathbf{u}} \\ \mathbf{F}_{\vartheta} \end{bmatrix}$$

- Stochastic model of the meso-scale random field: Spectral generator\*

- Start from the auto-/cross-covariance matrix

$$\tilde{R}_{\mathbf{v}'}^{(rs)}(\boldsymbol{\tau}) = \sigma_{\mathbf{v}'(r)} \sigma_{\mathbf{v}'(s)} R_{\mathbf{v}'}^{(rs)}(\boldsymbol{\tau}) = \mathbb{E} \left[ \left( \mathbf{v}'^{(r)}(\mathbf{x}) - \mathbb{E}(\mathbf{v}'^{(r)}) \right) \left( \mathbf{v}'^{(s)}(\mathbf{x} + \boldsymbol{\tau}) - \mathbb{E}(\mathbf{v}'^{(s)}) \right) \right]$$

- Evaluate the spectral density matrix from the periodized zero-padded matrix  $\tilde{R}_{\mathbf{v}'}^{\text{P}}(\boldsymbol{\tau})$

$$\mathbf{S}_{\mathbf{v}'}^{(rs)}[\boldsymbol{\omega}^{(m)}] = \sum_n \tilde{R}_{\mathbf{v}'}^{\text{P}}{}^{(rs)}[\boldsymbol{\tau}^{(n)}] e^{-2\pi i \boldsymbol{\tau}^{(n)} \cdot \boldsymbol{\omega}^{(m)}} \quad \& \quad \mathbf{S}_{\mathbf{v}'}[\boldsymbol{\omega}^{(m)}] = \mathbf{H}_{\mathbf{v}'}[\boldsymbol{\omega}^{(m)}] \mathbf{H}_{\mathbf{v}'}^*[\boldsymbol{\omega}^{(m)}]$$

- $\boldsymbol{\omega}$  gathers the discrete frequencies
- $\boldsymbol{\tau}$  gathers the discrete spatial locations

- Generate a Gaussian random field  $\mathbf{v}'(\mathbf{x}, \boldsymbol{\theta})$

$$\mathbf{v}'^{(r)}(\mathbf{x}, \boldsymbol{\theta}) = \sqrt{2\Delta\omega} \Re \left( \sum_s \sum_m \mathbf{H}_{\mathbf{v}'}^{(rs)}[\boldsymbol{\omega}^{(m)}] \eta^{(s,m)} e^{2\pi i (\mathbf{x} \cdot \boldsymbol{\omega}^{(m)} + \boldsymbol{\theta}^{(s,m)})} \right)$$

- $\boldsymbol{\eta}$  and  $\boldsymbol{\theta}$  are independent random variables

- Quid if a non-Gaussian distribution is sought?

\*Shinozuka, M., Deodatis, G., 1988

# The meso-scale random field

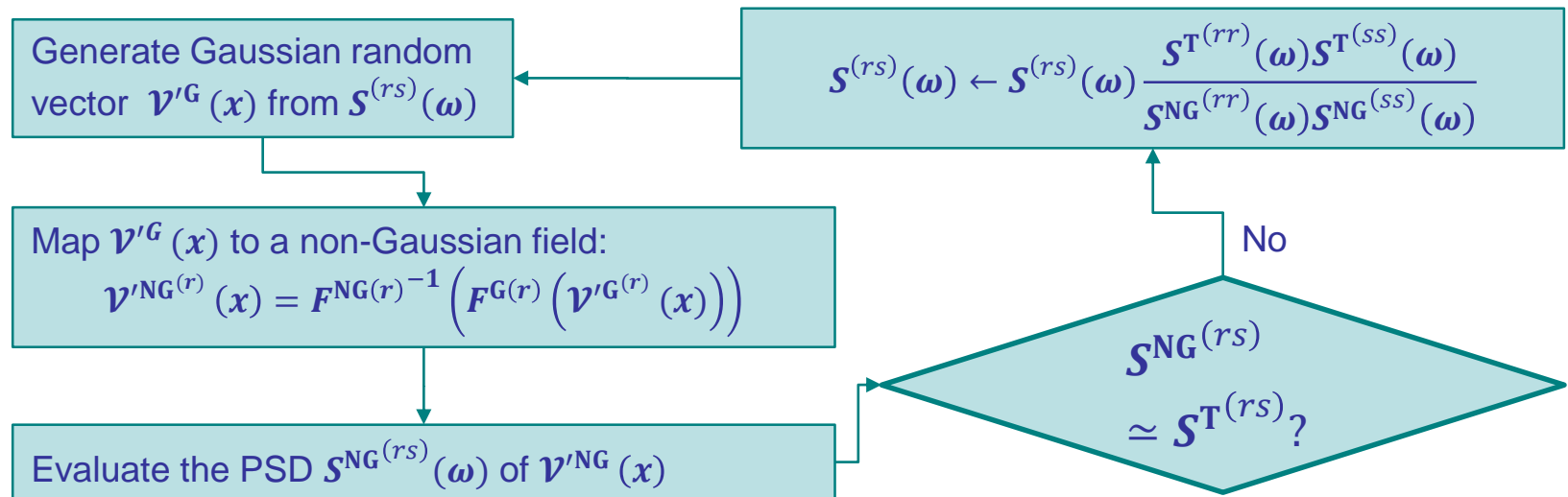
- Stochastic model of the meso-scale random field: non-Gaussian mapping\*
  - Start from micro-sampling of the stochastic homogenization

- The continuous form of the targeted PSD function

$$\mathcal{S}^{T(rs)}(\omega) = \Delta \tau \mathcal{S}_{\mathcal{V}'}^{(rs)}[\omega^{(m)}] = \Delta \tau \sum_n \tilde{R}_{\mathcal{V}'}^{\text{P}(rs)}[\tau^{(n)}] e^{-2\pi i \tau^{(n)} \cdot \omega^{(m)}}$$

- The targeted marginal distribution density function  $F^{\text{NG}(r)}$  of the random variable  $\mathcal{V}'^{(r)}$
- A marginal Gaussian distribution  $F^{\text{G}(r)}$  of zero-mean and targeted variance  $\sigma_{\mathcal{V}'^{(r)}}$

- Iterate



\*Deodatis, G., Micaletti, R., 2001